

MeChanICs

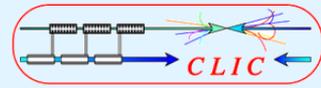
RF structure production

G. Riddone, 06/09/2010

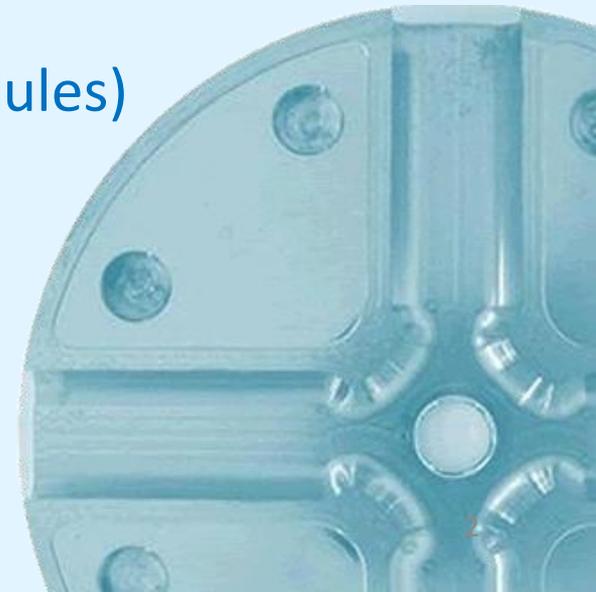




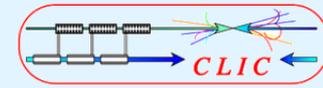
Content



- Introduction to RF structures and components
- Fabrication steps and issues
 - Engineering design
 - Machining
 - Quality control
 - Bonding
 - RF measurements
 - Baking
- Towards CLIC structures (CLIC two-beam modules)



Accelerating structures

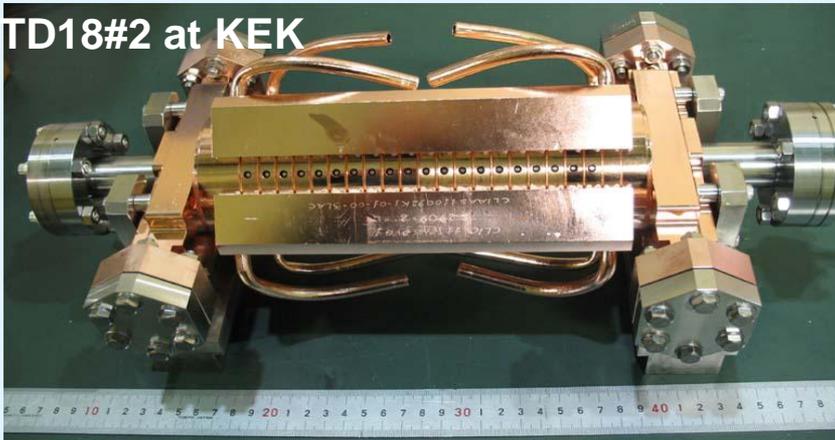


TD24#2 at CERN
(12 GHz)

TD18#3 at SLAC

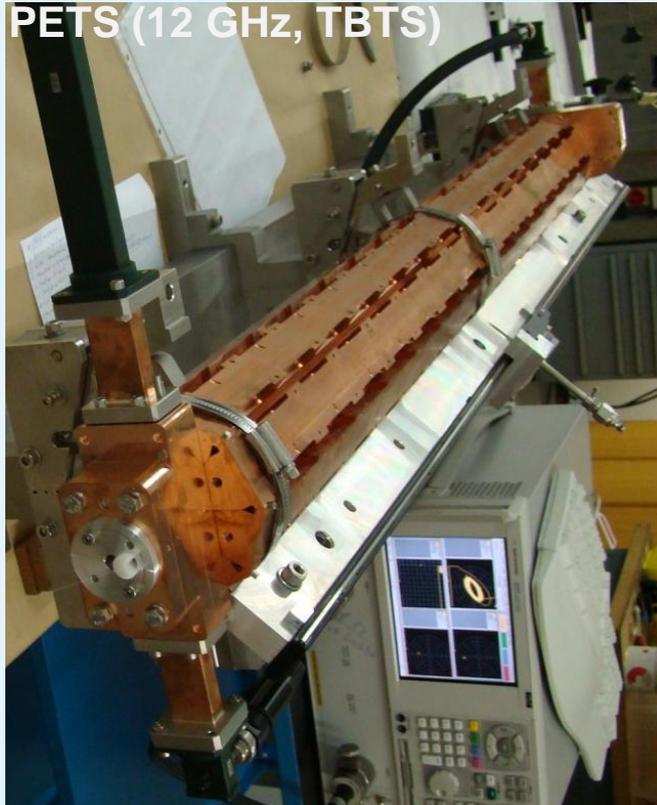


TD18#2 at KEK



- *Cu OFE UNS C10100*
- *Shape accuracy $\pm 2.5 \mu\text{m}$*
- *Roughness $R_a 0.025 \mu\text{m}$*
- *\varnothing 45 to 80 mm, 30 disks*
- *Length 300 mm*

PETS (12 GHz, TBTS)

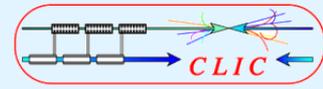


PETS (11.4 GHz, test at SLAC)

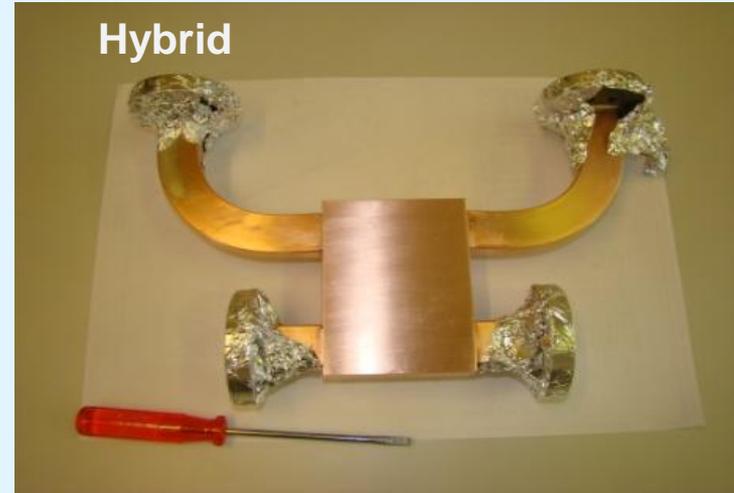


- *Cu OFE UNS C10100*
- *Shape accuracy $\pm 7.5 \mu\text{m}$*
- *Roughness $R_a 0.1 \mu\text{m}$*
- *8 octants*
- *Length 300-1000 mm*

RF components



High-power dry load



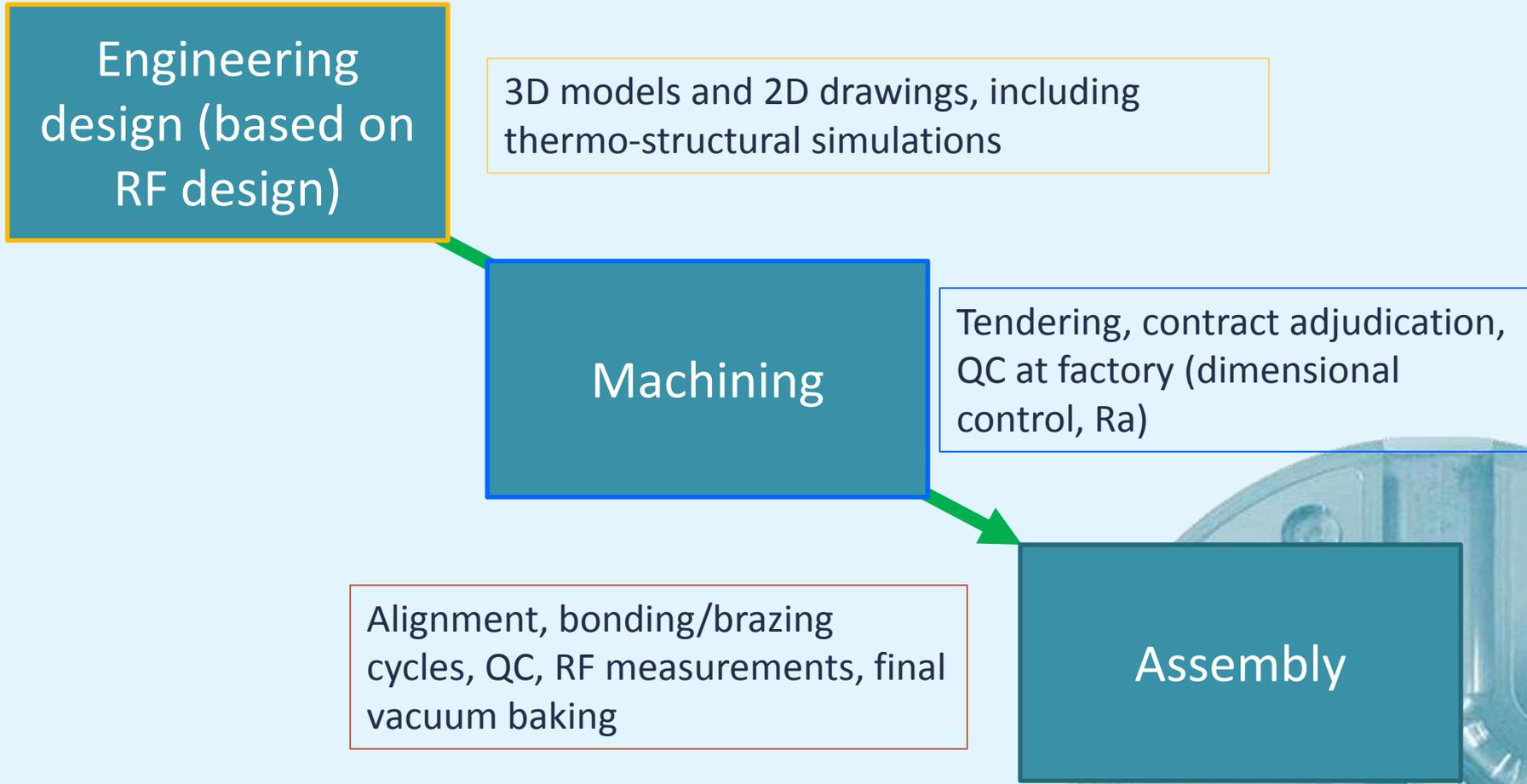
Hybrid

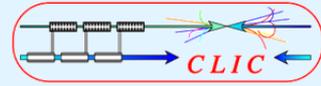


Variable high power splitter

Not treated in this talk.

Production phases

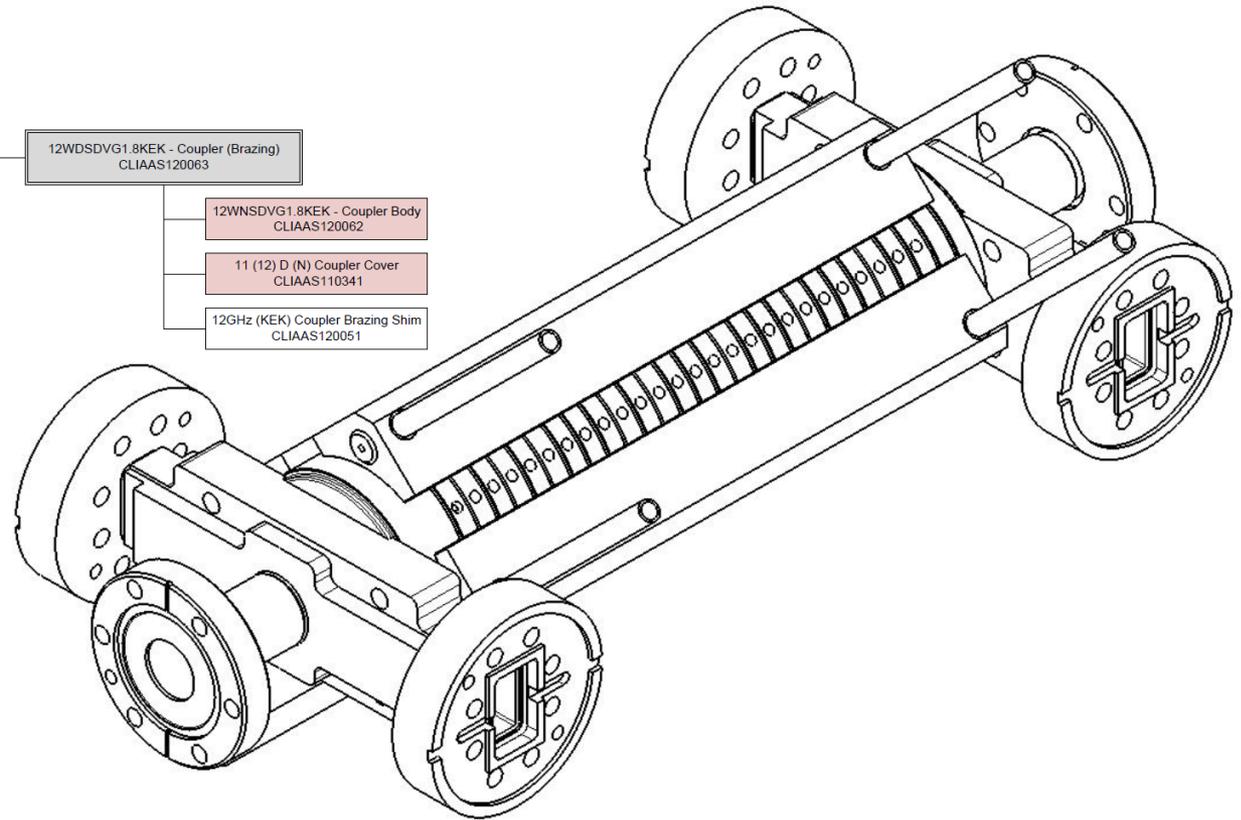
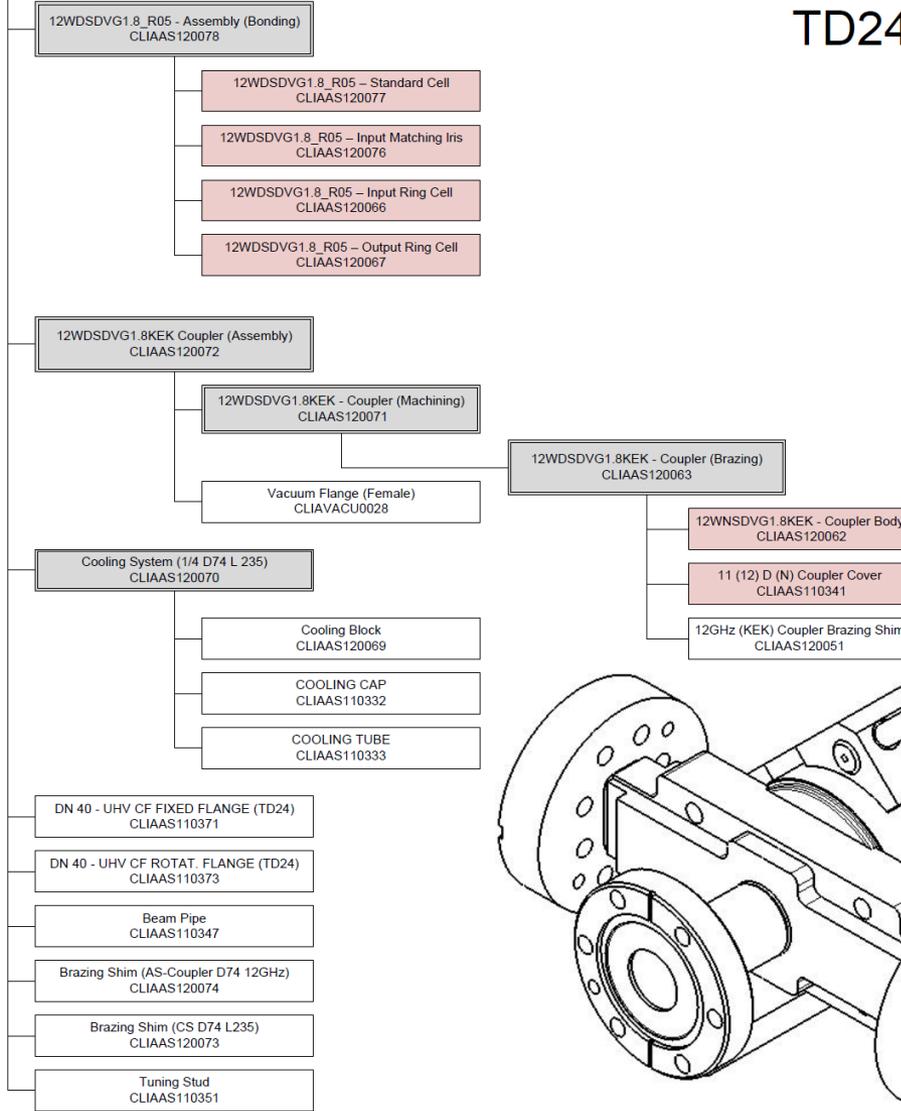


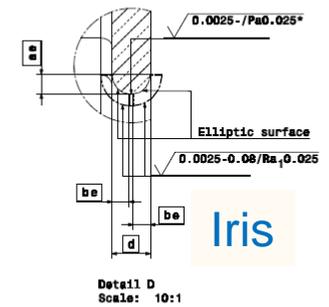
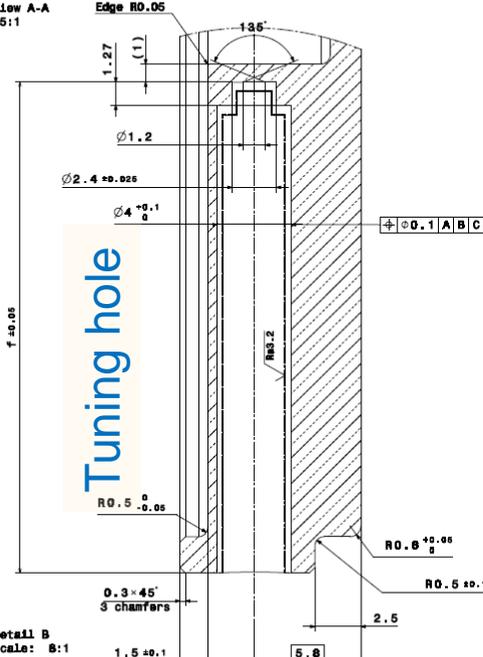
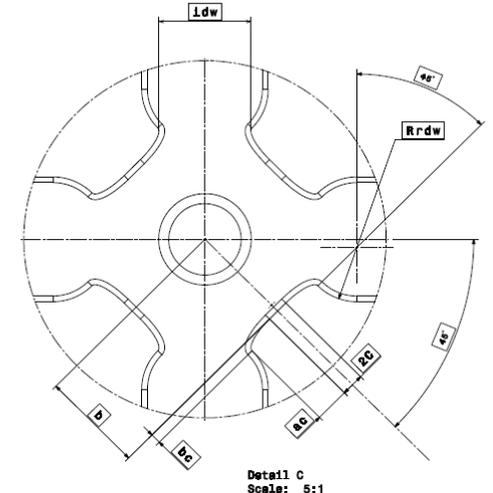
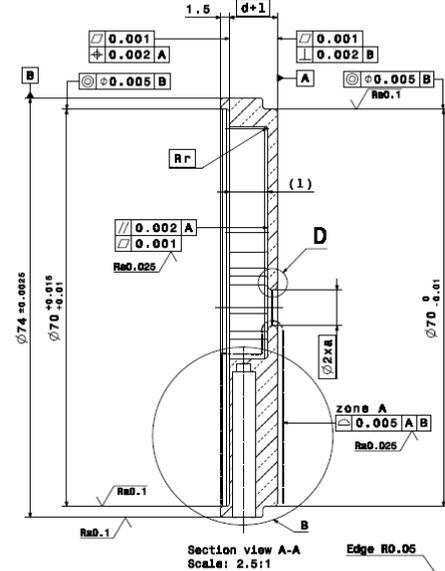
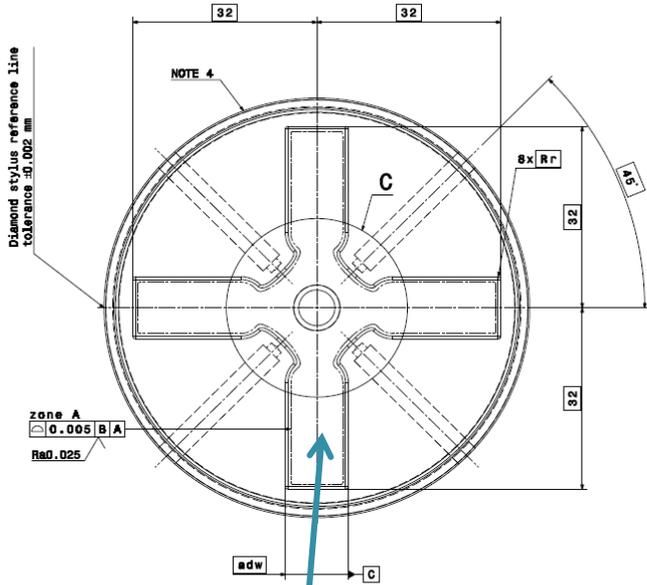


ENGINEERING DESIGN



12WDSVDVG1.8_R05 (Sealed) TD24 KEK-SLAC based design





Damping waveguide

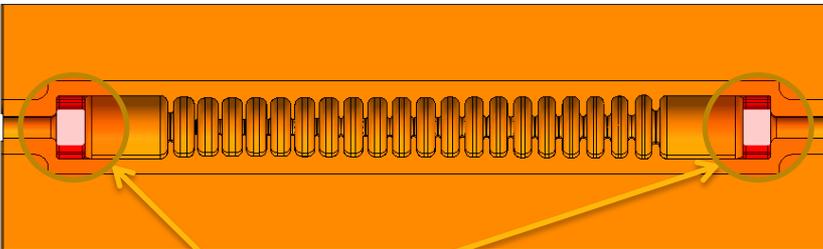
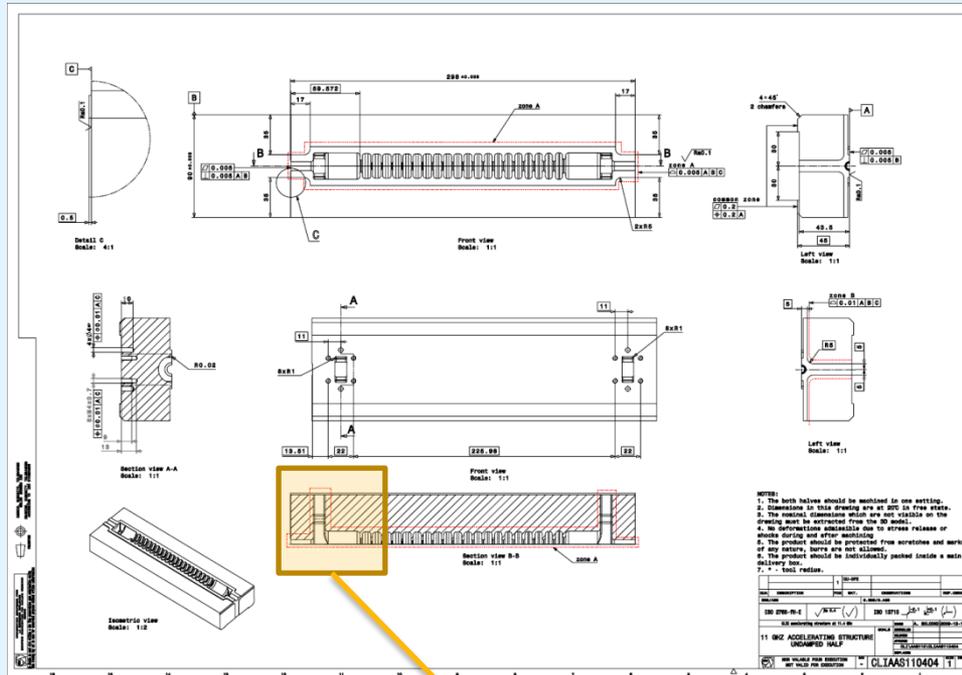
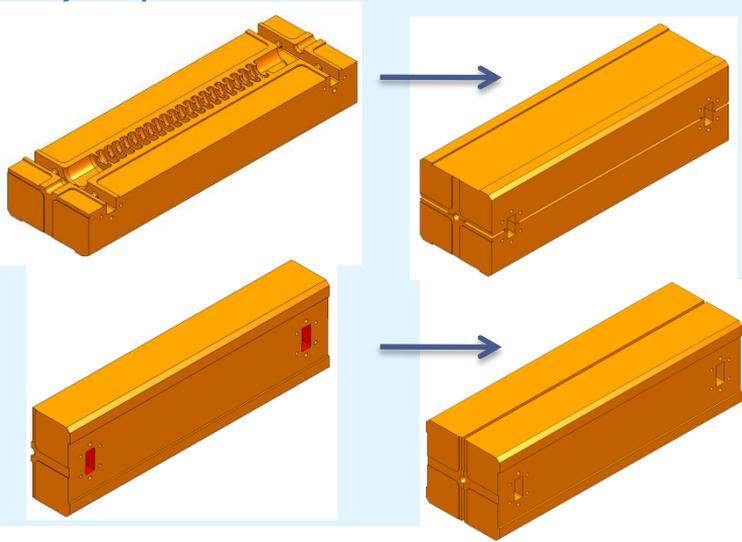
N	Cell	a (mm)	d (mm)	b (mm)	c (mm)	l (mm)	e (mm)	ae (mm)	adw (mm)	idw (mm)	r (mm)	bc (mm)	ac (mm)	rdw (mm)
1	MATCH CELL A	3.15	1.67	6.9417	1	6.682	3.4	0.877020583	11	0	0.5	0.896128004	3.053835212	4.809080481
2	REGULAR CELL 1	3.1167	1.6421	6.8149	0.6267	6.676	3.3858	0.861603249	11	0	0.5	0.917858924	3.116868729	4.801830696
3	REGULAR CELL 2	3.0833	1.6142	6.6902	0.62	6.7038	3.3875	0.846198557	11	0	0.5	0.916297219	3.110731829	4.800927309
4	REGULAR CELL 3	3.05	1.5882	6.5693	0.6133	6.7318	3.3792	0.830742258	11	0	0.5	0.918815941	3.104862828	4.798901283
5	REGULAR CELL 4	3.0167	1.5583	6.5769	0.6067	6.7597	3.3708	0.815355214	11	0	0.5	0.919412148	3.099154463	4.799014542
6	REGULAR CELL 5	2.9833	1.5304	6.5645	0.6	6.7878	3.3625	0.799882861	11	0	0.5	0.920989804	3.093822933	4.798011623
7	REGULAR CELL 6	2.95	1.5025	6.5524	0.5933	6.8155	3.3542	0.784817447	11	0	0.5	0.922663895	3.088761008	4.796874519
8	REGULAR CELL 7	2.9167	1.4748	6.5406	0.5867	6.8435	3.3458	0.769283738	11	0	0.5	0.921751347	3.083985858	4.795880876
9	REGULAR CELL 8	2.8833	1.4487	6.529	0.58	6.8714	3.3375	0.753925501	11	0	0.5	0.922728325	3.078909122	4.794758444
10	REGULAR CELL 9	2.85	1.4188	6.5177	0.5733	6.8993	3.3292	0.738595059	11	0	0.5	0.923834133	3.073628594	4.793587741
11	REGULAR CELL 10	2.8167	1.3898	6.5066	0.5667	6.9272	3.3208	0.723220172	11	0	0.5	0.925021944	3.07181254	4.792371542
12	REGULAR CELL 11	2.7833	1.3628	6.4958	0.56	6.9551	3.3125	0.707920115	11	0	0.5	0.926343235	3.068519867	4.79111141
13	REGULAR CELL 12	2.75	1.335	6.4852	0.5533	6.983	3.3042	0.692830298	11	0	0.5	0.927754121	3.065485167	4.789813321
14	REGULAR CELL 13	2.7167	1.3071	6.4749	0.5467	7.011	3.2958	0.677354681	11	0	0.5	0.929281748	3.062759743	4.788453866
15	REGULAR CELL 14	2.6833	1.2792	6.4648	0.54	7.0388	3.2875	0.66207014	11	0	0.5	0.93092545	3.060417417	4.787063341
16	REGULAR CELL 15	2.65	1.2513	6.4548	0.5333	7.068	3.2792	0.6468851947	11	0	0.5	0.932681367	3.058215915	4.785647802
17	REGULAR CELL 16	2.6167	1.2233	6.4451	0.5267	7.0947	3.2708	0.631593289	11	0	0.5	0.934425231	3.056319047	4.784168334
18	REGULAR CELL 17	2.5833	1.1954	6.4355	0.52	7.1228	3.2625	0.616363138	11	0	0.5	0.936287301	3.054689844	4.782671105
19	REGULAR CELL 18	2.55	1.1675	6.4262	0.5133	7.1505	3.2542	0.601157017	11	0	0.5	0.938265825	3.053343814	4.781117188
20	REGULAR CELL 19	2.5167	1.1396	6.417	0.5067	7.1784	3.2458	0.585978702	11	0	0.5	0.940364464	3.052234978	4.779527487
21	REGULAR CELL 20	2.4833	1.1117	6.408	0.5	7.2064	3.2375	0.570821752	11	0	0.5	0.942584139	3.0514219	4.777903316
22	REGULAR CELL 21	2.45	1.0838	6.3993	0.4933	7.2343	3.2292	0.555681174	11	0	0.5	0.944828326	3.05102413	4.776220233
23	REGULAR CELL 22	2.4167	1.0558	6.3908	0.4867	7.2622	3.2208	0.540503282	11	0	0.5	0.947217848	3.050799244	4.774483912
24	REGULAR CELL 23	2.3833	1.0279	6.3825	0.48	7.2901	3.2125	0.52540849	11	0	0.5	0.949719208	3.050896318	4.772711188
25	REGULAR CELL 24	2.35	1	6.3745	0.4733	7.318	3.2042	0.510328802	11	0	0.5	0.952357943	3.051545322	4.770877034
26	MATCH IRIS B	4.263	1	6.62138	0.85	7.332	3.2	0.48334748	11	0	0.5	0.896781085	2.878131508	4.790173823

- NOTES:
- Dimensions in this drawing are at 20°C in free state.
 - Lubricant based on Chlorine or Sulfur should be avoided. No polishing is allowed.
 - No deformations admissible due to stress release or shocks during and after machining.
 - The product should be marked with present drawing.
 - To be protected against scratches and marks of any nature, burrs are not allowed.
 - The product must be individually packed inside a main delivery box.
 - * - Evaluation length is equal to (d-2*) mm
 - Roughness is according to ISO 1302
 - The present drawing is based on KEK drawing XK1401-01

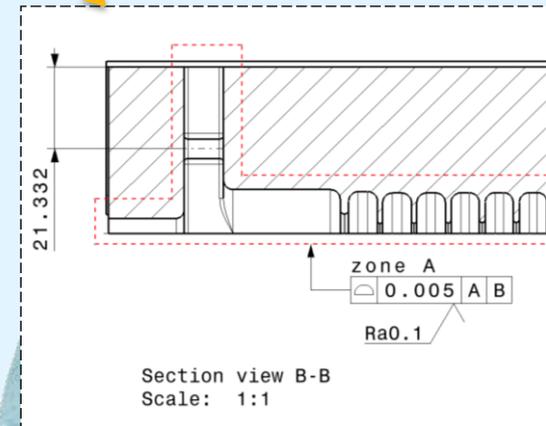
1		QU-DFE		
DATA	DESCRIPTION	POS	INT.	OBSERVATIONS
ENG/ASD				ENG/ASD
ISO 2780-TH-E		√ N 9.8	ISO 13715	ISO 1302
CLC manufacturing structure at 12 Hz				
12WSDV01.8 R05		SCALE	CONTROLLED	DATE
STANDARD CELL		2.6:1	RELEASED	2010-07-28
		APPROVED	REWORK	2010-07-28
		REPLACES	CLIAAS120077	
RELEASED BY	FOR PROJECT ENGINEER	INFO	DATE	SIZE
			CLIAAS120077	1

HALVES

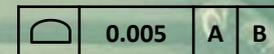
Accelerating structure – 11WNSHVG1



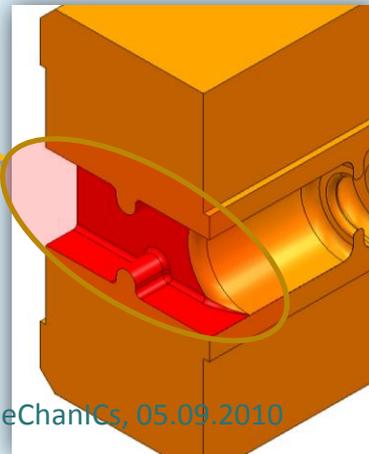
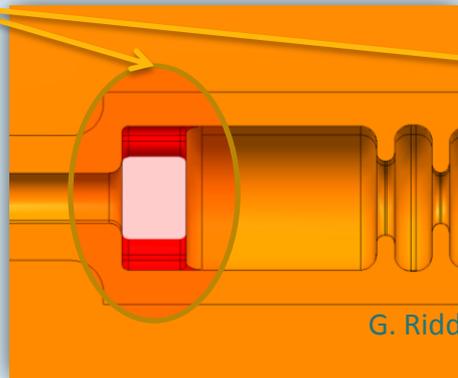
Section view of critical area



Geometrical tolerance of this zone

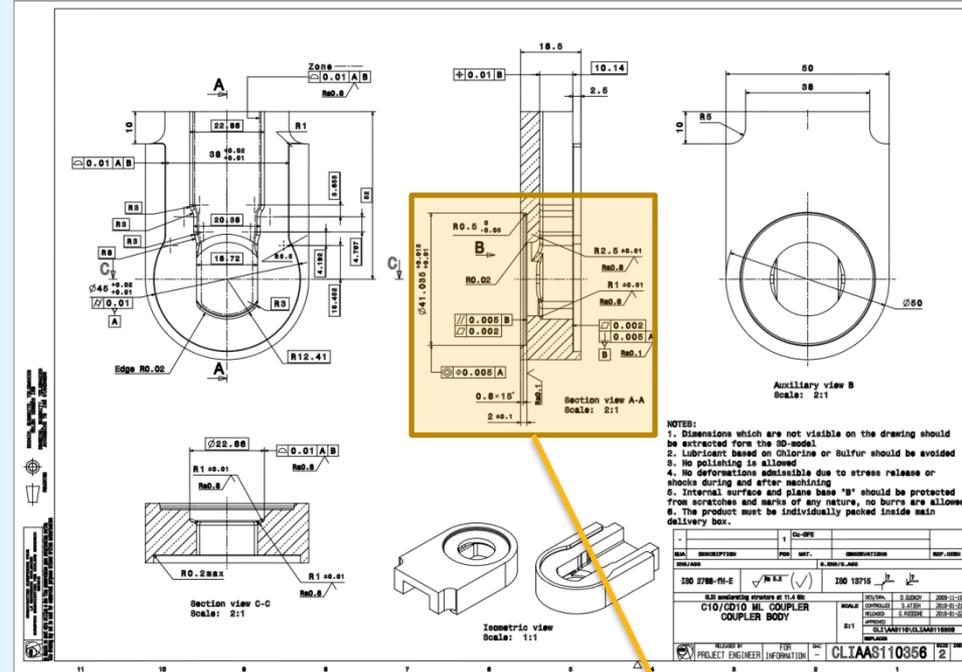
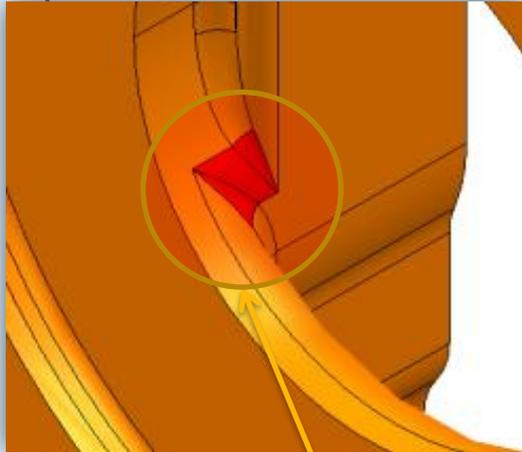


WAVEGUIDES

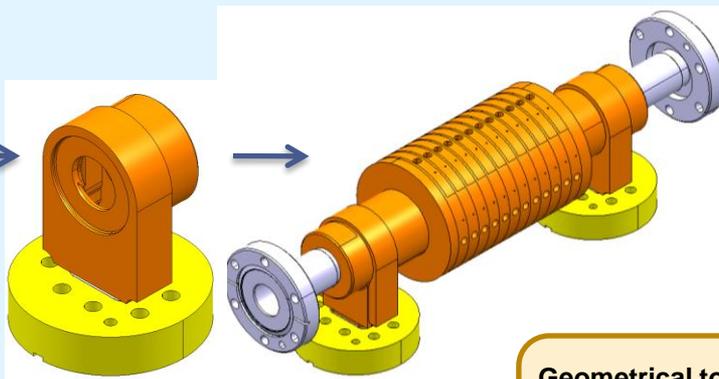
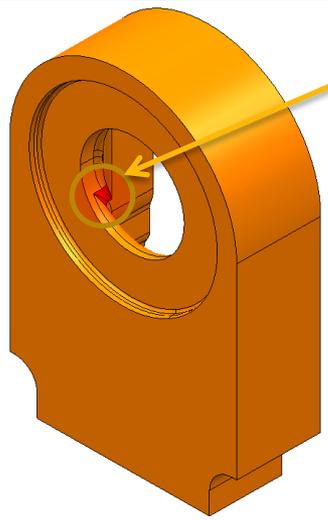


Mode Launcher COUPLER

Accelerating structure – 12CDSD1.2ML

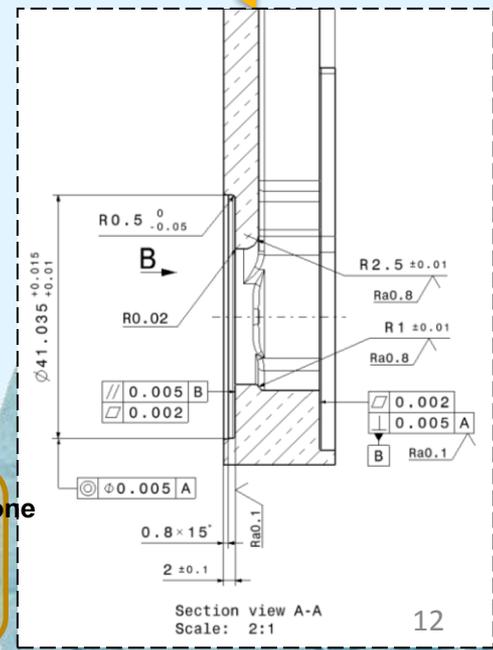


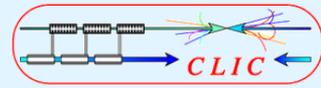
Critical area



Geometrical tolerance of this zone

	0.01	A	B
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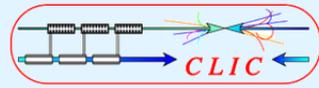




Engineering design: To be studied/optimised

- Reduction of types of tooling
- Tolerances requirements: review of regions with stringent and relaxed tolerances
- Review of roughness requirements in the different regions
- Optimization of design for chosen assembly/joining methods



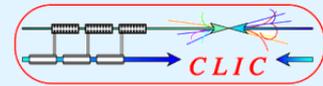


MACHINING AND DIMENSIONAL CONTROL

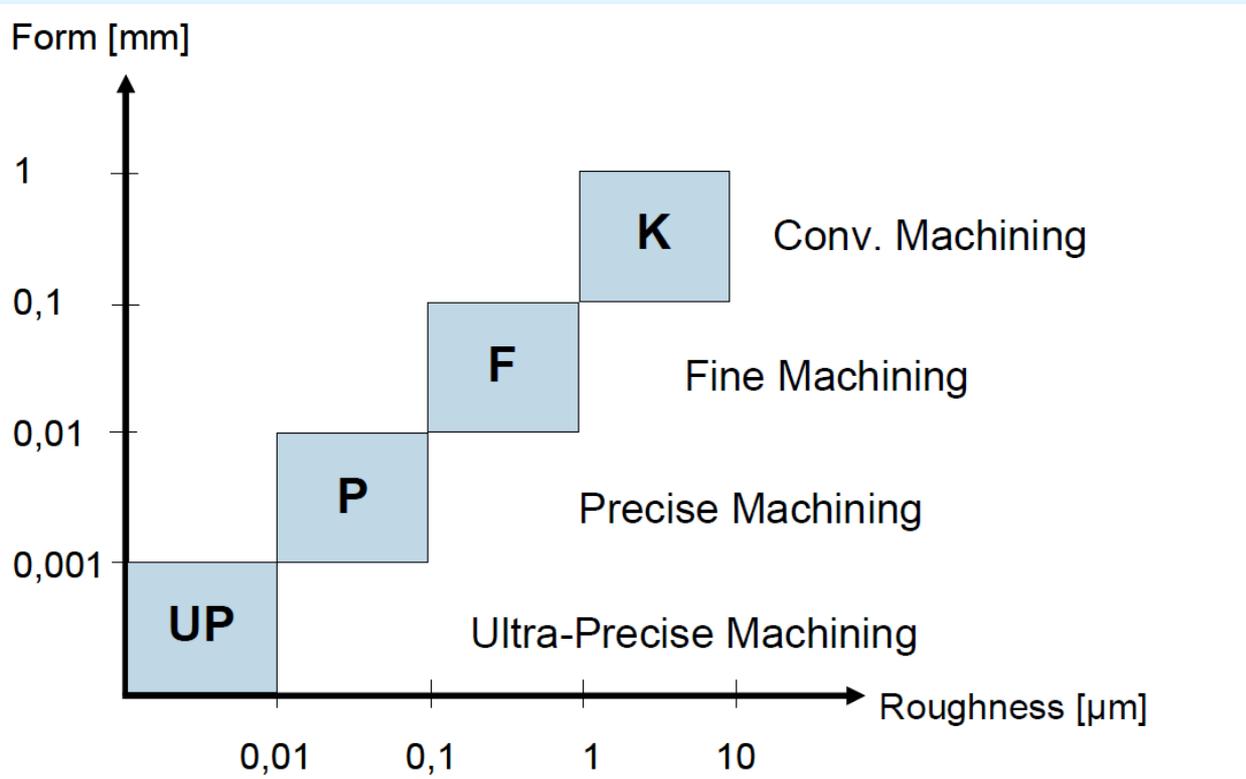




Why Ultra-Precision Machining



CLIC's needs:
shape accuracy $\pm 2 \mu\text{m}$
Roughness Ra 25 nm



Technology

- Accelerating structures
 - Milling and turning (disks) -BASELINE
 - Milling (quadrants/halves) - ALTERNATIVE
 - Annealing steps between pre-machining and finishing

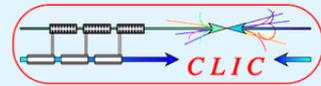
- PETS
 - Milling
 - Annealing steps between pre-machining and finishing

Diamond tool is required

- *Dimensional stability*
- *Maintenance of tolerances*
- *Chips do not adhere to surface*
- *Expensive → well characterised*



Machining at VDL



Enabling Technologies Group Inspection Report **VDL**

Drawing no. CLAAAS120020 Prod. Nr. 1

Description 12WDSVDVG1.8T disk 007

Measurand	Description	Nominal	Upper		Lower	Pass	Fail	Remark
			+	-				
1	Ref A $\phi 0.002$	0.0000	0.0020	0.0000	0.0015	✓	✗	
2	Outer diameter Ref B	80.0000	0.0050	0.0050	0.0004	0.0004	✓	
3	$\phi 0.002$	0.0000	0.0010	0.0000	0.0005	0.0005	✓	
4	$\phi 0.005$ A	0.0000	0.0000	0.0000	0.0001	✓		
5	Width of cross Z+	0.0025	0.0025	0.0025	0.0022	0.0022	✓	
6	Width of cross Z-	0.0025	0.0025	0.0025	0.2514	0.0114	✓	
7	Width of cross Y+	11.2500	0.0025	0.0025	11.2501	0.0001	✓	
8	Width of cross Y-	11.2500	0.0025	0.0025	11.2501	0.0001	✓	
9	Plane cross A $\phi 0.002$	0.0000	0.0025	-0.0025	8.3171	-0.0004	✓	
10	Plane cross B $\phi 0.002$	0.0000	0.0020	0.0000	0.0006	0.0006	✓	
11	Depth of recess Ref A $\phi 0.002$	0.0000	0.0050	0.0000	0.0036	0.0036	✓	
11	Cross $\phi 0.005$ A	6.8368	0.0025	-0.0025	6.8364	-0.0004	✓	
12	Bottom plane cross $\phi 0.002$	0.0000	0.0020	0.0000	0.0011	0.0011	✓	
13	Depth of recess for solder tail	0.0300	0.0100	0.0000	0.0382	0.0082	✓	
14	Diameter undulation	5.8478	0.0025	-0.0025	5.8469	-0.0009	✓	
15	$\phi 0.002$	0.0000	0.0020	0.0000	0.0004	0.0004	✓	
17	$\phi 0.003$ B	0.0000	0.0030	0.0000	0.0012	0.0012	✓	
9	Measurand t	1.4807	0.0025	-0.0025	1.4801	-0.0008	✓	
18	Undulation $\phi 0.005$ A B	0.0000	0.0050	0.0000	0.0038	0.0038	✓	
19	Cross $\phi 0.005$ A	0.0000	0.0050	0.0000	0.0026	0.0015	✓	

All dimensional checks are compliant

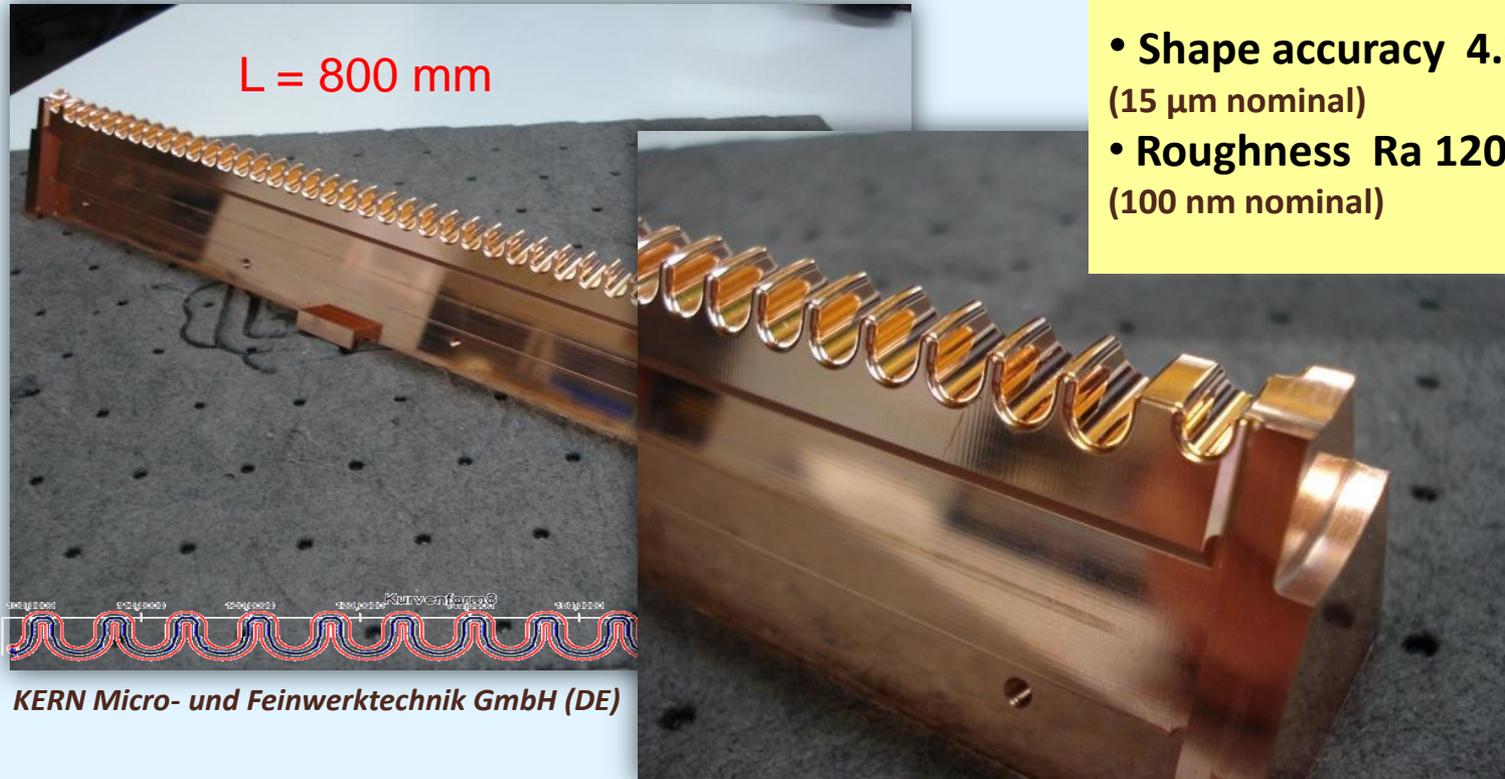
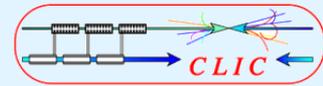
Disk 8.1

Damped disk at 12 GHz



New CMM (Coordinate Measuring Machine) at CERN

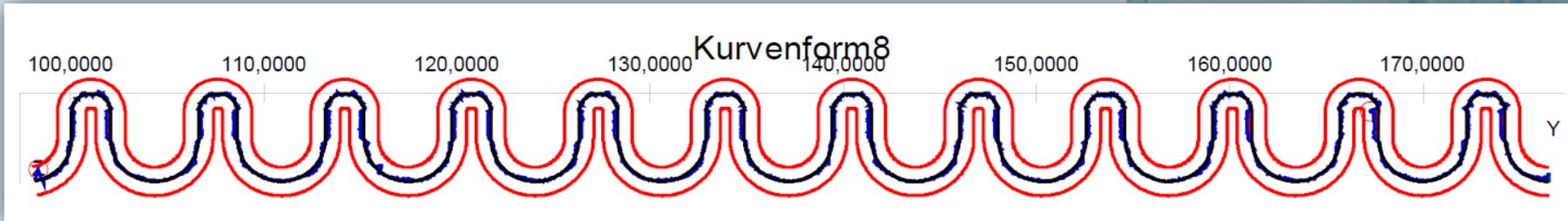
PETS (CLIAP11_0037)



- **Shape accuracy 4.8 μm**
(15 μm nominal)
- **Roughness Ra 120 -180 nm**
(100 nm nominal)



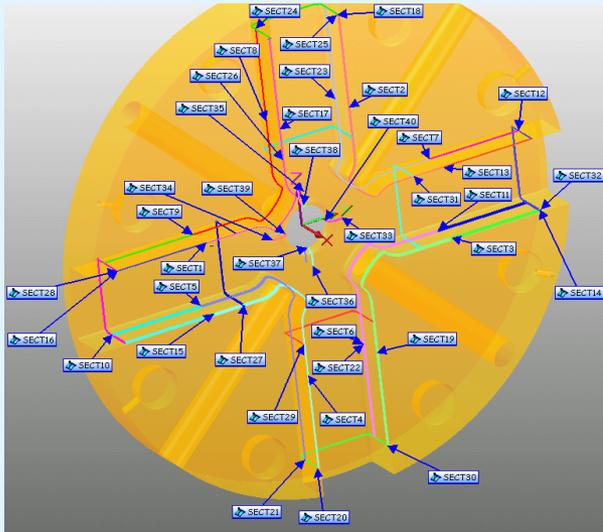
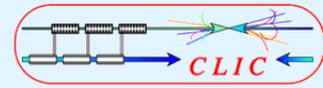
KERN Micro- und Feinwerktechnik GmbH (DE)



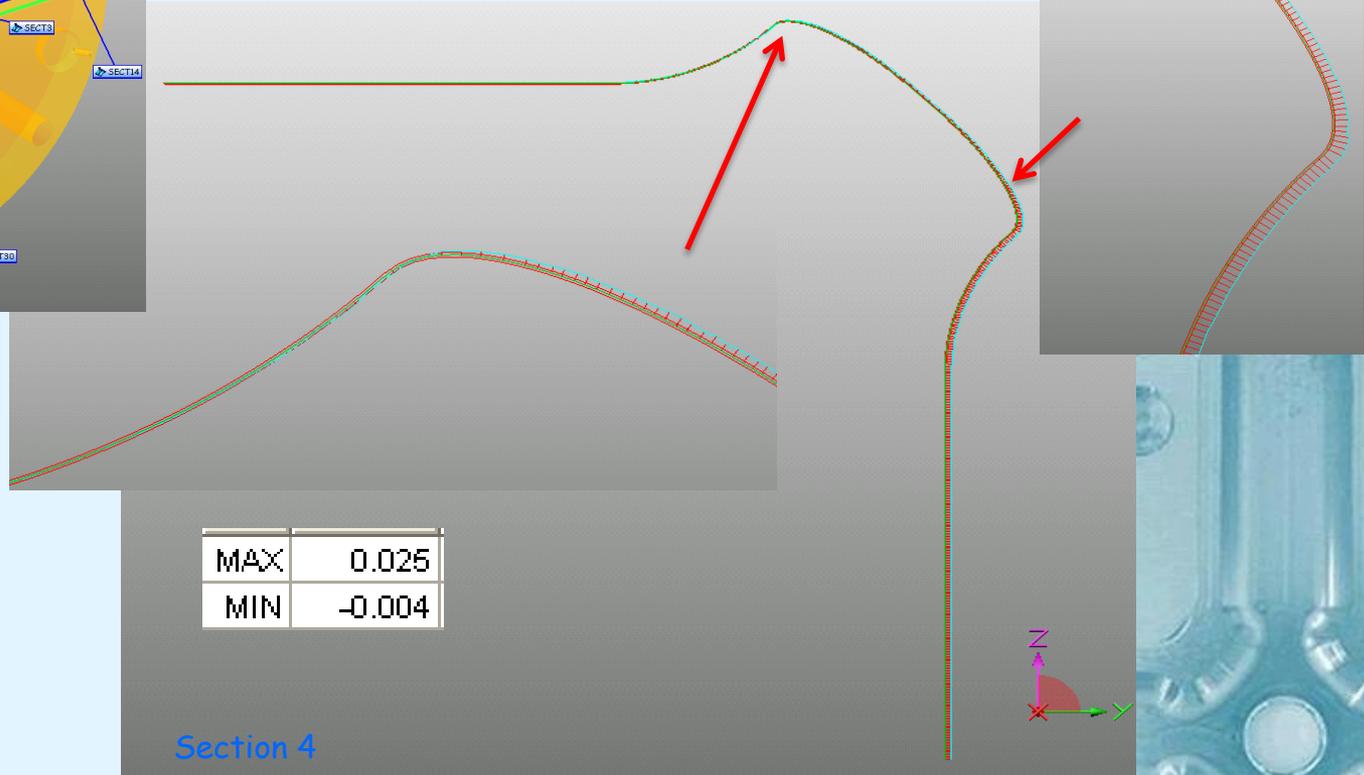


Damped disk

CLIAAS110070 VTT (FI)

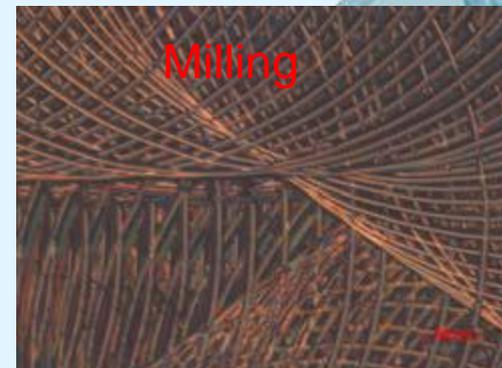
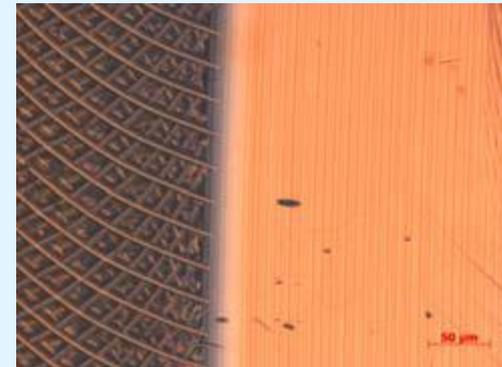
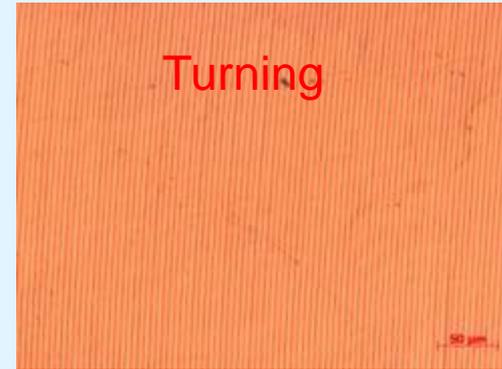
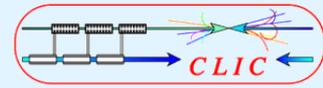


Shape accuracy of 50 μm (Deviation due localisation errors)
 Very accurate and stable shape
 Fabricated by milling



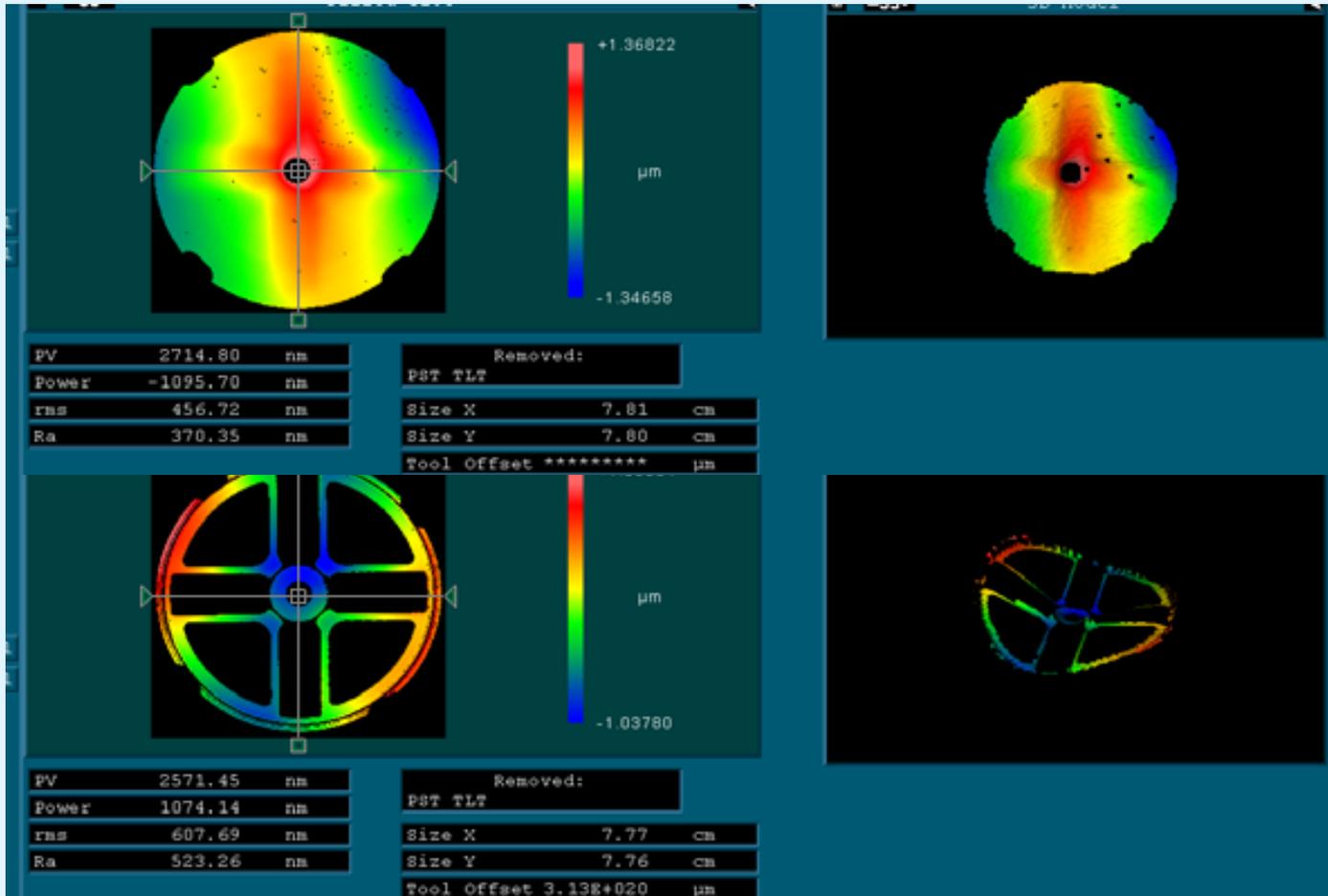
Damped disk

CLIAAS110188 (VDL)



Damped disk

CLIAAS110188 (VDL)



Leitz PMM-C Infinity

Measuring range in mm:

X = 1200, Y = 1000, Z = 700

Volumetric length measuring error:

$E = 0.3 + L / 1000$ [μm]

Volumetric probing error: P = 0.4 μm

Resolution: 0.004 μm

Continuous Scanning Probe head LSP-S4 ANF

- probing force : 1g – 6g

-max. Styli weight : 450g

-max. Styli extension : 500mm

-max. Probing frequency: 6 – 8
pts/min

-max Moving speed: 80 mm/sec

-max. Acceleration: 100 mm/sec²

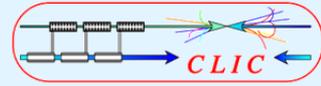


Machining:

To be studied/optimised

- Machining and annealing steps:
 - When and at which temperature (and how long)
- Unique clamping device for turning and milling
- Tool geometry and wear
- Turning vs milling regions: turning as much as possible
- Optimization of dimensional control procedure



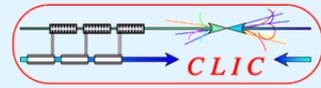


ASSEMBLY





Assembly of accelerating structures



T18 structures tested at SLAC/KEK showed excellent test results



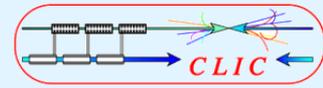
consequent validation of design, machining and assembly procedure



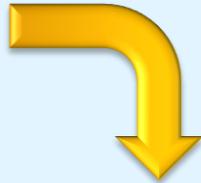
NLC/JLC fabrication technology: validated to 100 MV/m (baseline for future CERN X-band accelerating structures)



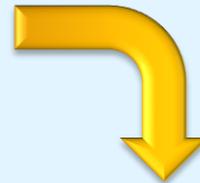
Baseline procedure



Diamond machining (**sealed structures**)



Cleaning with light etch

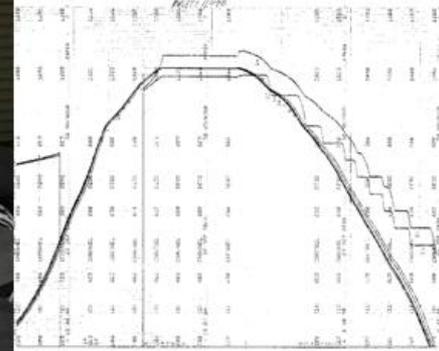


H₂ diffusion bonding/brazing at ~ 1000 °C



Vacuum baking 650 °C > 10 days

Diffusion Bonding of T18_vg2.4_DISC



Pressure: 60 PSI (60 LB for this structure disks)
Holding for 1 hour at 1020°C

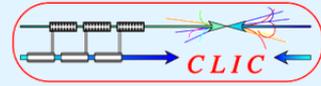
J. Wuang

Vacuum Baking of T18_vg2.4_DISC



650° C
10 days

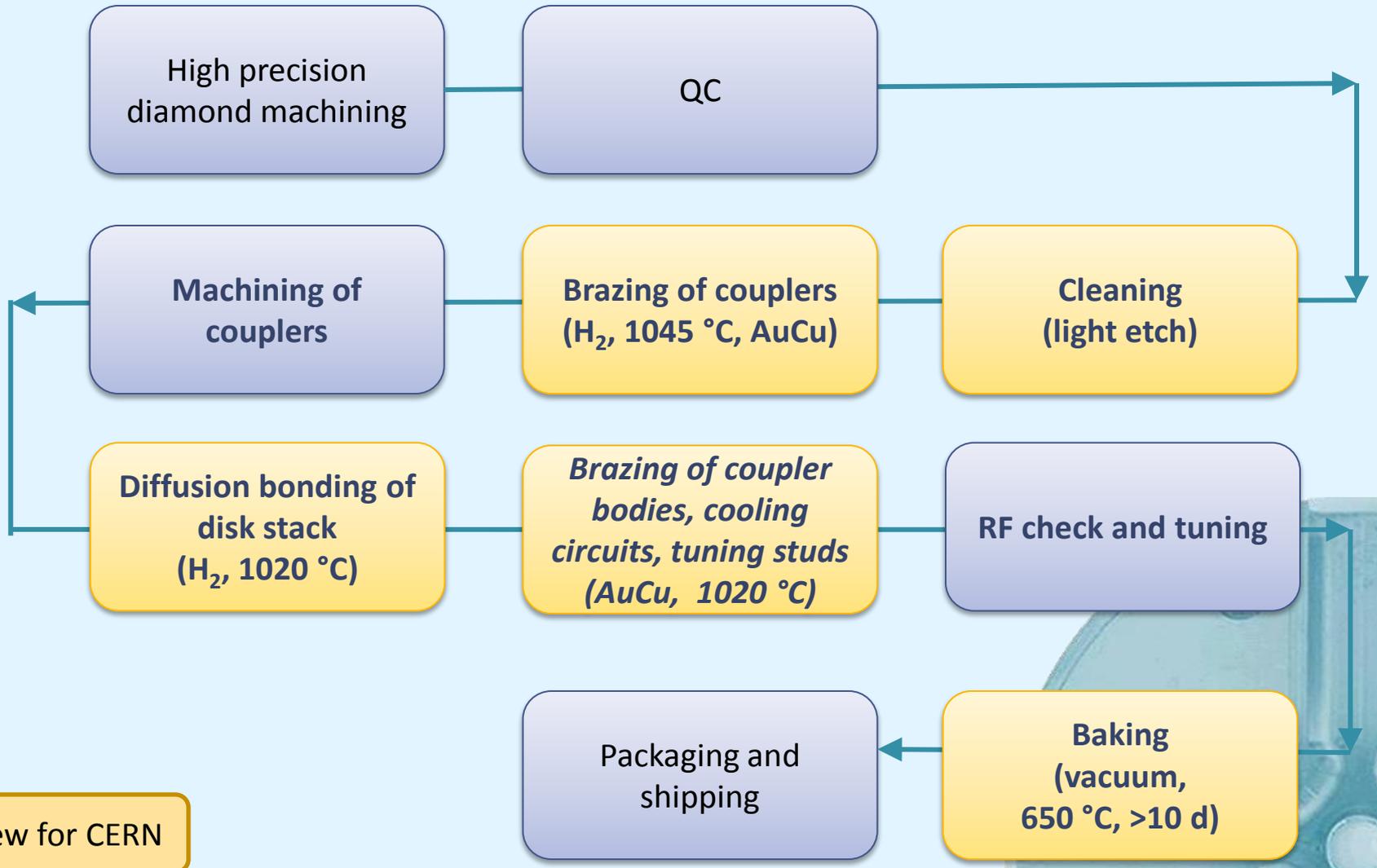
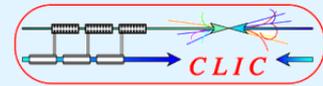
J. Wuang



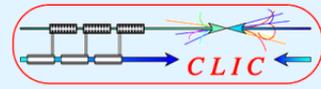
Application to CERN accelerating structures

- CERN previous assembly procedure was based on vacuum brazing at 800 °C → **several changes were needed for implementing the baseline procedure**
- Following the post-mortem analysis of the two CERN accelerating structures T18 and T24, contamination (C, Ca) resulted to be the main problem → **cleanliness had to be seriously improved**

Baseline manufacturing flow



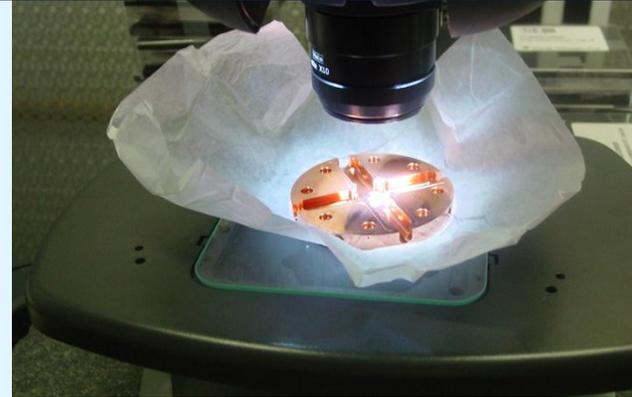
Inspections



Microscopic inspections before and after each relevant fabrication step



Microscopic inspection of disks before and after cleaning (on witness pieces)



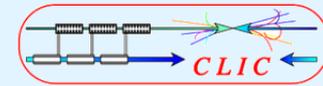
Video inspections, SEM and microscopic inspections

T18 KEK/SLAC design





Cleaning



Cleaning of Accelerator Parts

For accelerator structure parts with single diamond tuning surfaces:

1. Vapor degrease in 1,1,1 trichloroethane or equivalent degreaser for 5 minutes.
2. Alkaline soak clean in Enbond Q527 for 5 minutes at 180°F.
3. Cold tap water rinse for 2 minutes.
4. Immense in 50% hydrochloric acid at room temperature for 1 minutes.
5. Cold tap water rinse for 1 minute.
6. Immense in the following solution for maximum of 5 seconds depending on the surface finish required:

Phosphoric Acid, 75%	21 gallons
Nitric Acid, 42° Baume	7 gallons
Acetic Acid, Glacial	2 gallons
Hydrochloric Acid	12.6 fluid ounces
Temperature	Room
7. Cold tap water rinse for minimum of 2 minutes until the film on part disappears.
8. Ultrasonic in DI Water for 1 minute.
9. Ultrasonic in new, clean alcohol for 1 minute.
10. Final Rinse to be done in new, clean alcohol.
11. Hold in clean alcohol in stainless steel containers.
12. Dry in a clean room using filtered N2.

For accelerator structure parts with regular machining surfaces:

6. Immense in the following solution for maximum of 30-60 seconds depending on the surface finish required:

J. Wuang

Etching



G. Riddone, MeChanICS, 05.09.2010

SLAC cleaning procedure as a baseline

For degreasing

Trichloroethane → at SLAC replaced by Perchloroethylene

CERN procedure:

(Firm AVANTEC Performance Chemicals):

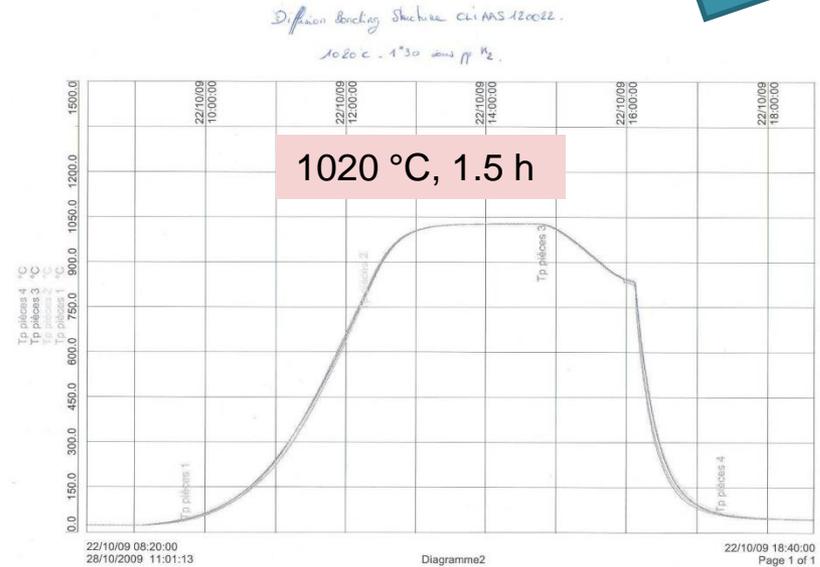
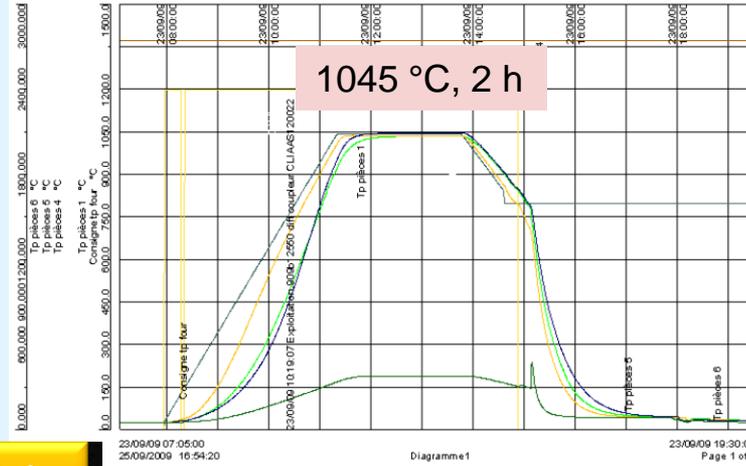
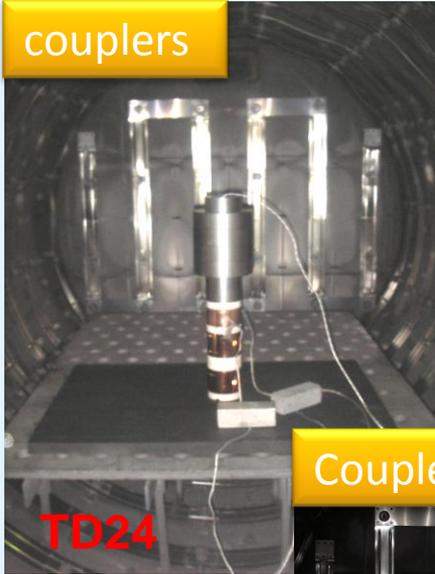
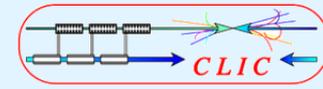
- TOPKLEAN MC 20A
- PROMOSOLV 71IPA



Tool for holding the disks

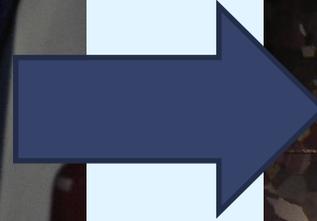
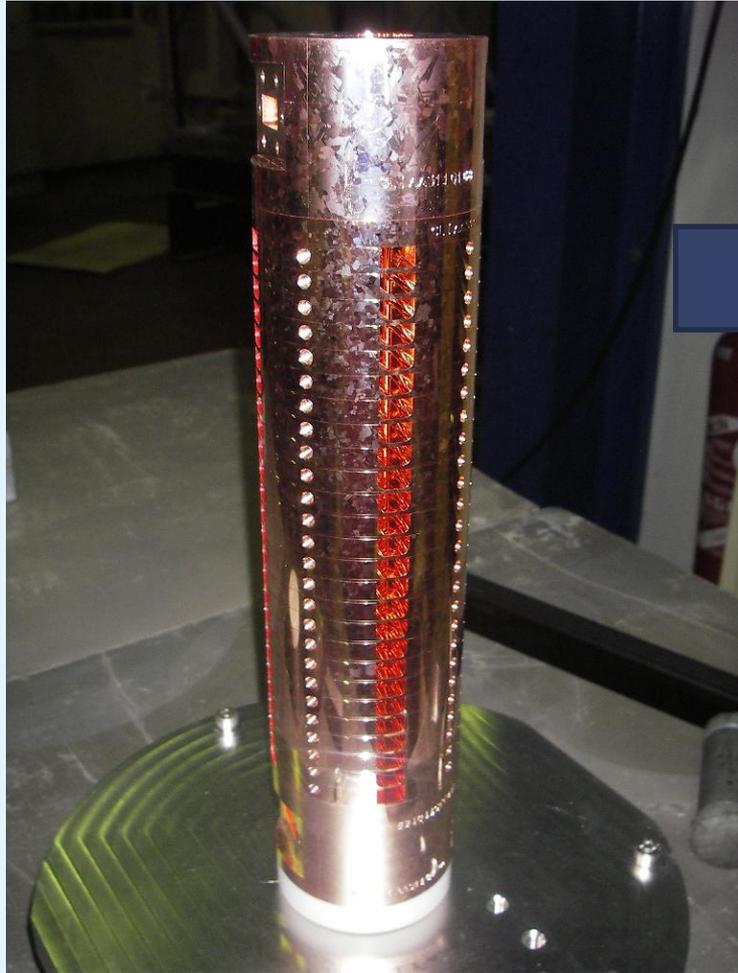
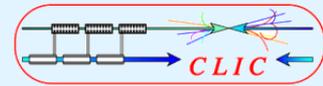


Diffusion bonding

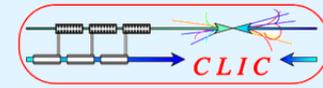


Bonding at CERN: few mbar H₂ partial pressure (difference with SLAC): we are validating bonding at 1 bar H₂ (Thales-CEA, Listenmann).

Accelerating structure TD24 after diffusion bonding under H_2

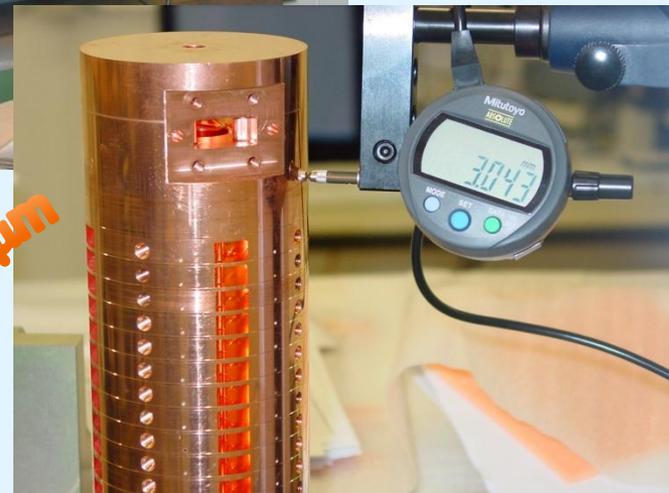


Assembly

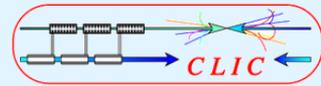


Assembly made on V-blocks
Verification of the assembly
(before and after bonding) with a
new measurement column:
straightness and tilt

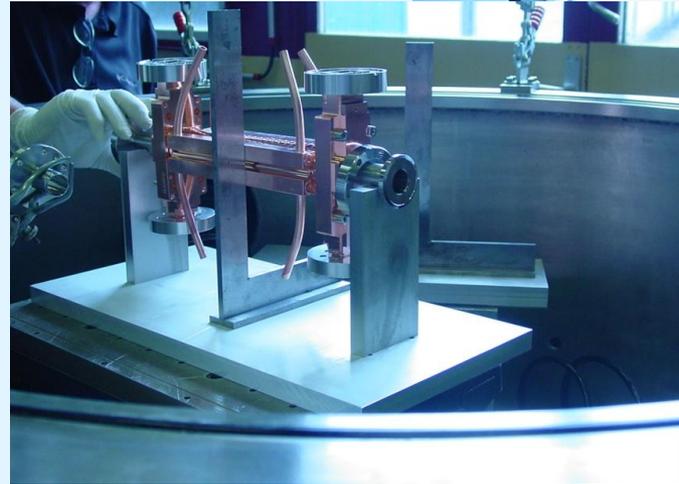
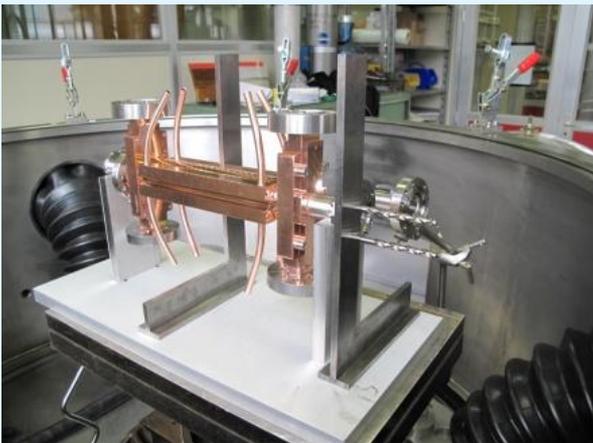
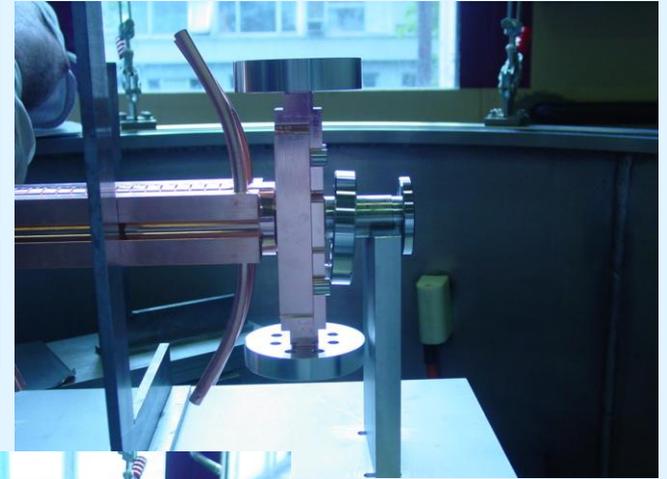
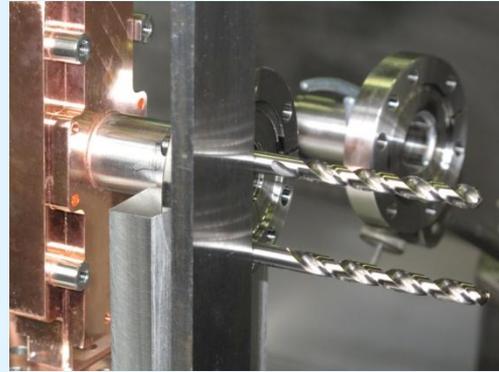
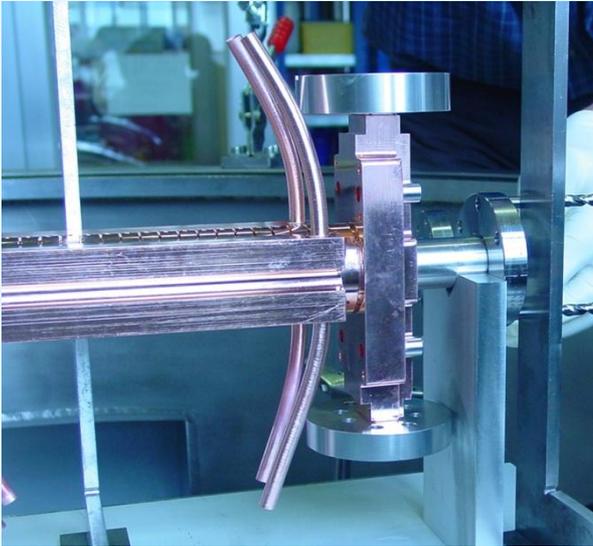
**Straightness
measurement $\pm 2 \mu\text{m}$**



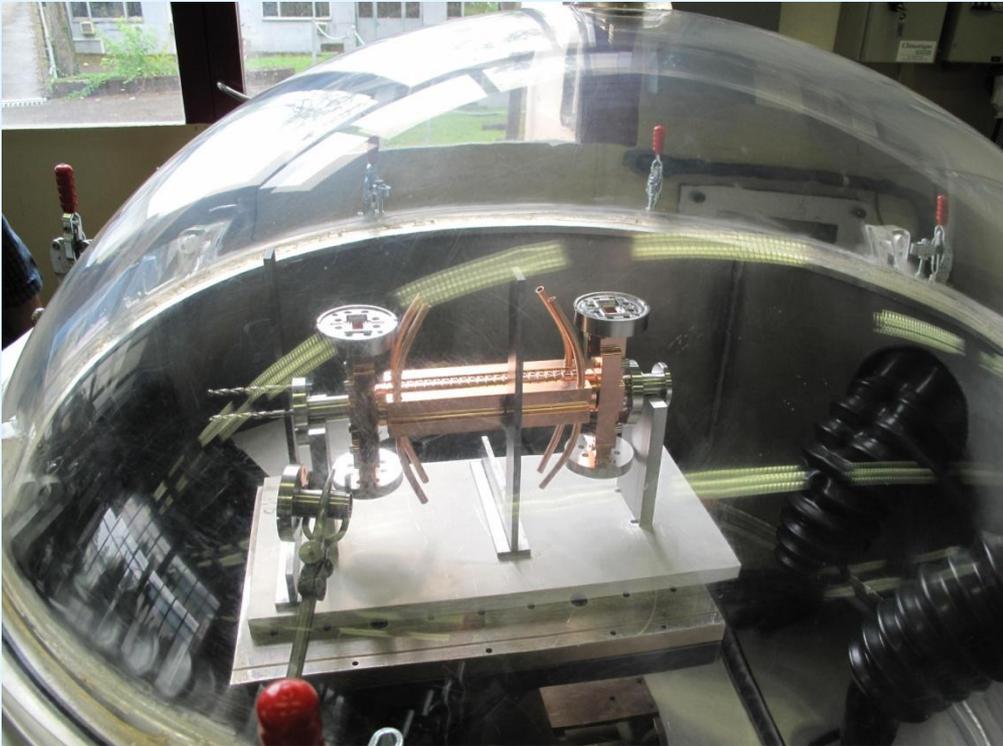
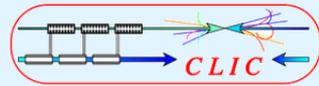
Welding of the vacuum flanges



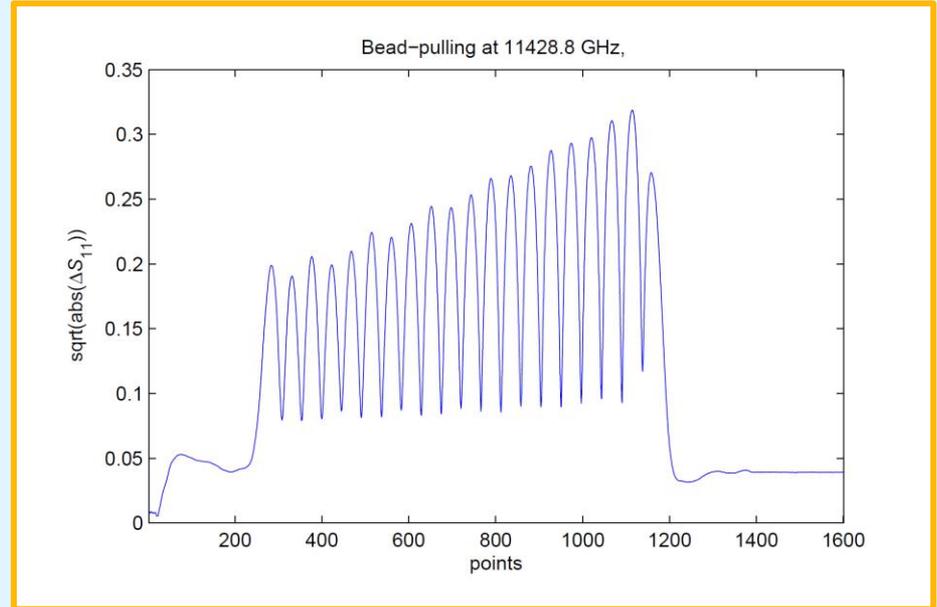
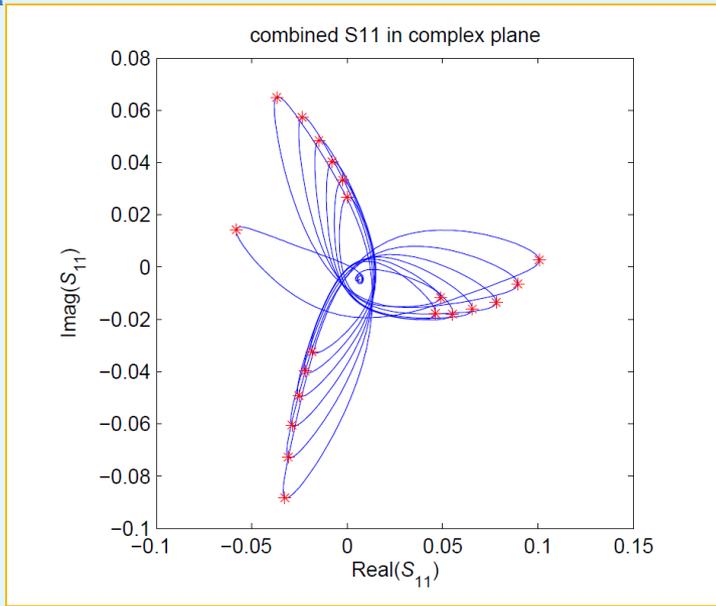
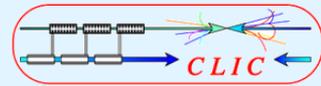
Under Argon 13 l/min in a glove box



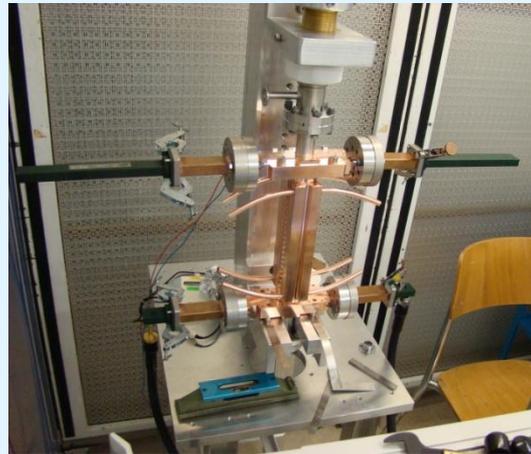
Welding of the vacuum flanges



RF check and tuning

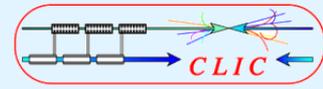


J. Shi





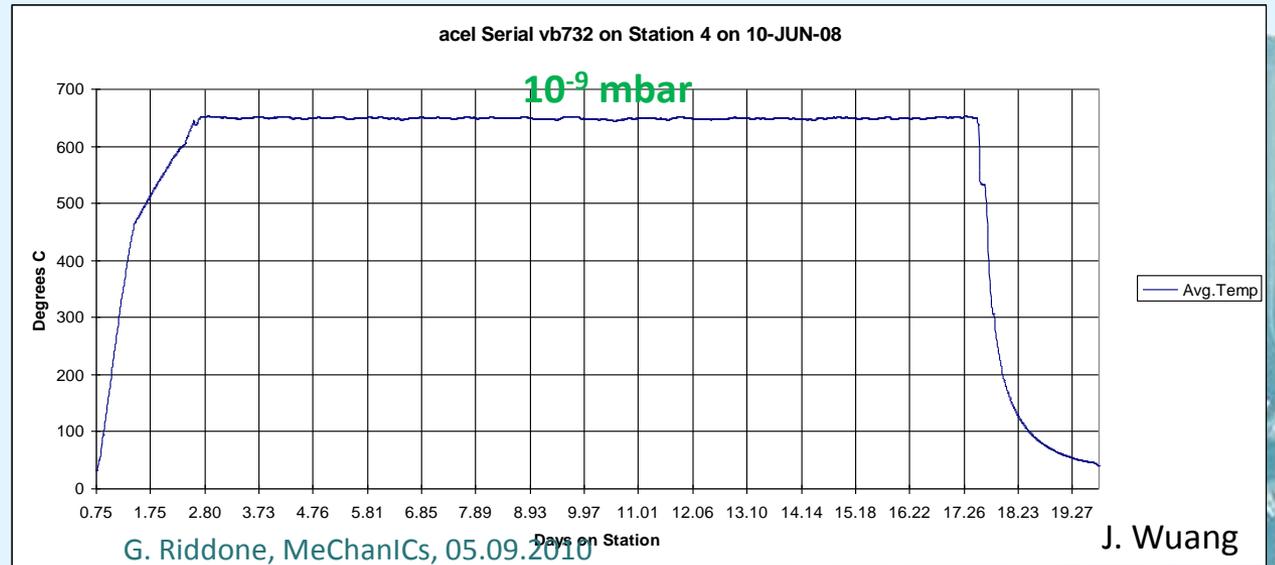
Vacuum baking



CERN furnace
→ several mechanical adaptations were needed



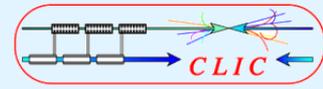
1st baking: TD24 for CLEX, two-beam test stand



G. Riddone, MeChanICs, 05.09.2010

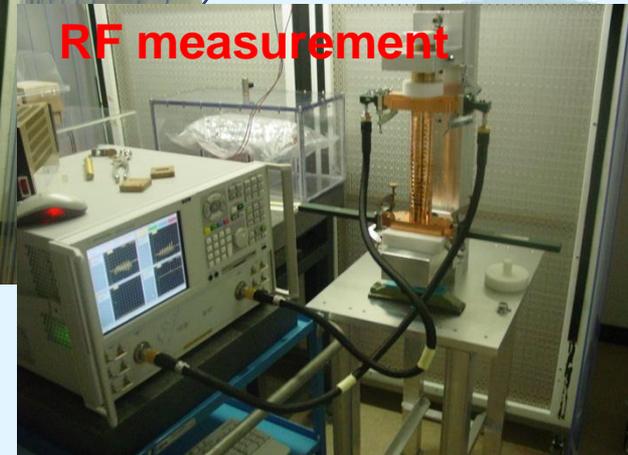
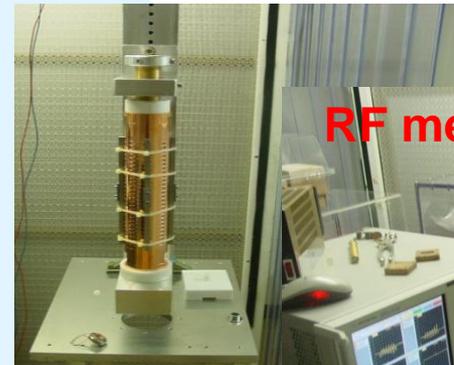
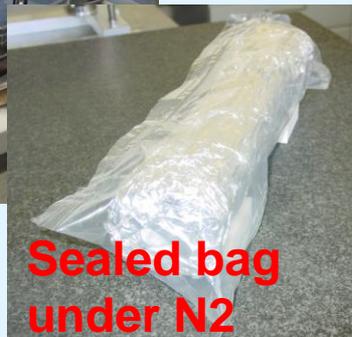
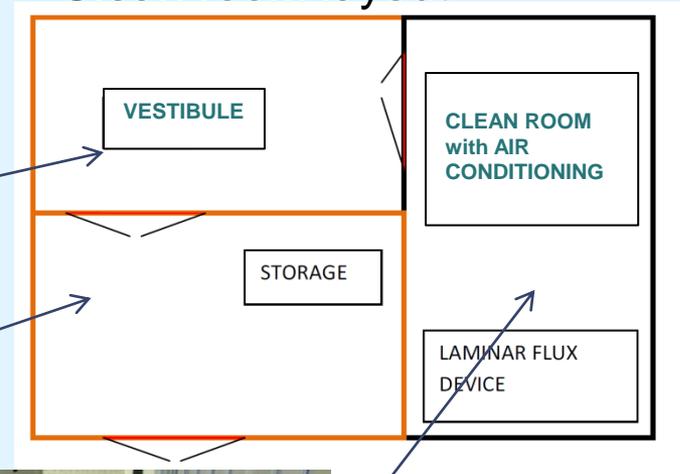
J. Wuang

Clean room



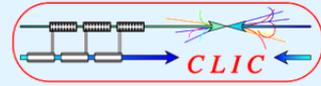
S. Lebet, visit this afternoon

Clean room layout





Production base program



F = under fabrication
D = under eng. design

2010
CDR
2011
2013

F T24 undamped

F TD24 damped

F TD24 R05 KS
reduced ΔT

D TD24 R05 KS – reduced ΔT with
damping loads

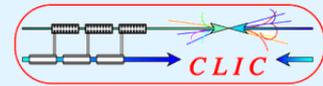
D TD26 KS
– reduced ΔT with damping loads
and compact coupler

F TD24 – with
wakefield monitors

D CLIC structures with all features and
technical systems
(Stand alone + Test Module)



Accelerating structures fabrication procedure comparison



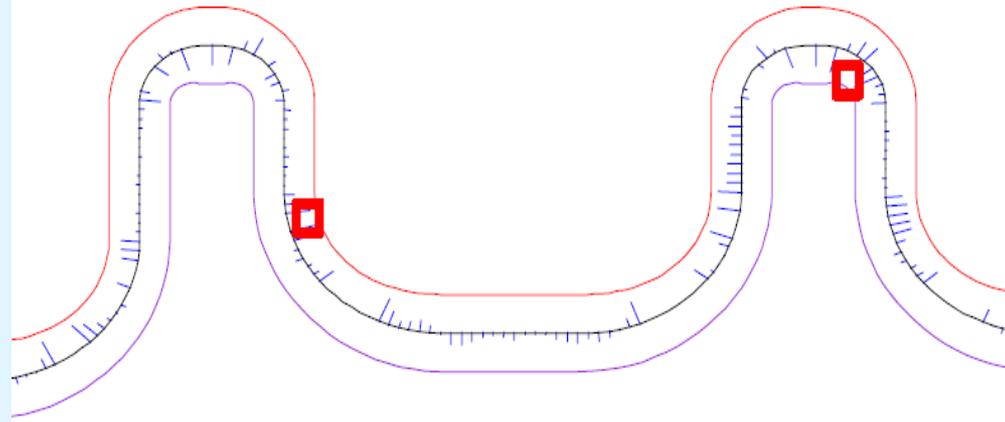
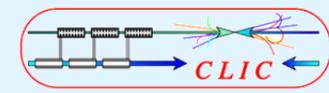
	SLAC/KEK	Fermilab	CERN old	CERN new (SLAC/KEK based)
Diamond machining	✓	✓	✓	✓
Etch	✓	✓	✓	✓
1000 °C pre-fire		✓ (Ar)		
~ 1000 °C diffusion bonding	✓			✓
~ 1000 °C brazing	✓			
~ 800 °C brazing		✓ (Ar, Au/Cu)	✓ (Vacuum, Ag/Cu)	✓
Vacuum baking	✓	✓		✓
Tank/sealed	SEALED	SEALED	SEALED	TANK /SEALED

CERN procedure still needs to be optimised

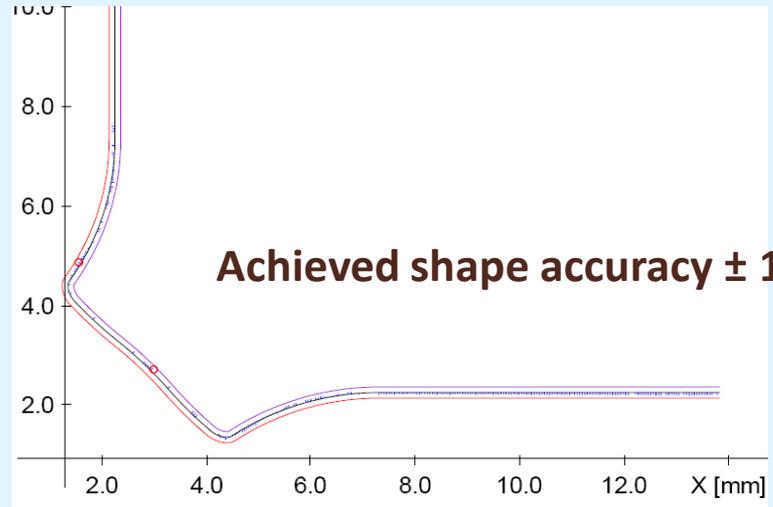


S. Atieh

Accelerating structures: alternative program



Achieved shape accuracy $\pm 2.1 \mu\text{m}$
Roughness $R_a = 86 \text{ nm} - 30 \text{ nm}$ according to ISO 97



Achieved shape accuracy $\pm 1.3 \mu\text{m}$



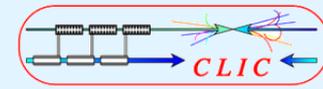
QUADRANTS - HDS thick qualification part according to CLIAAS300062 - KERN

G. Riddone, MeChanICs, 05.09.2010

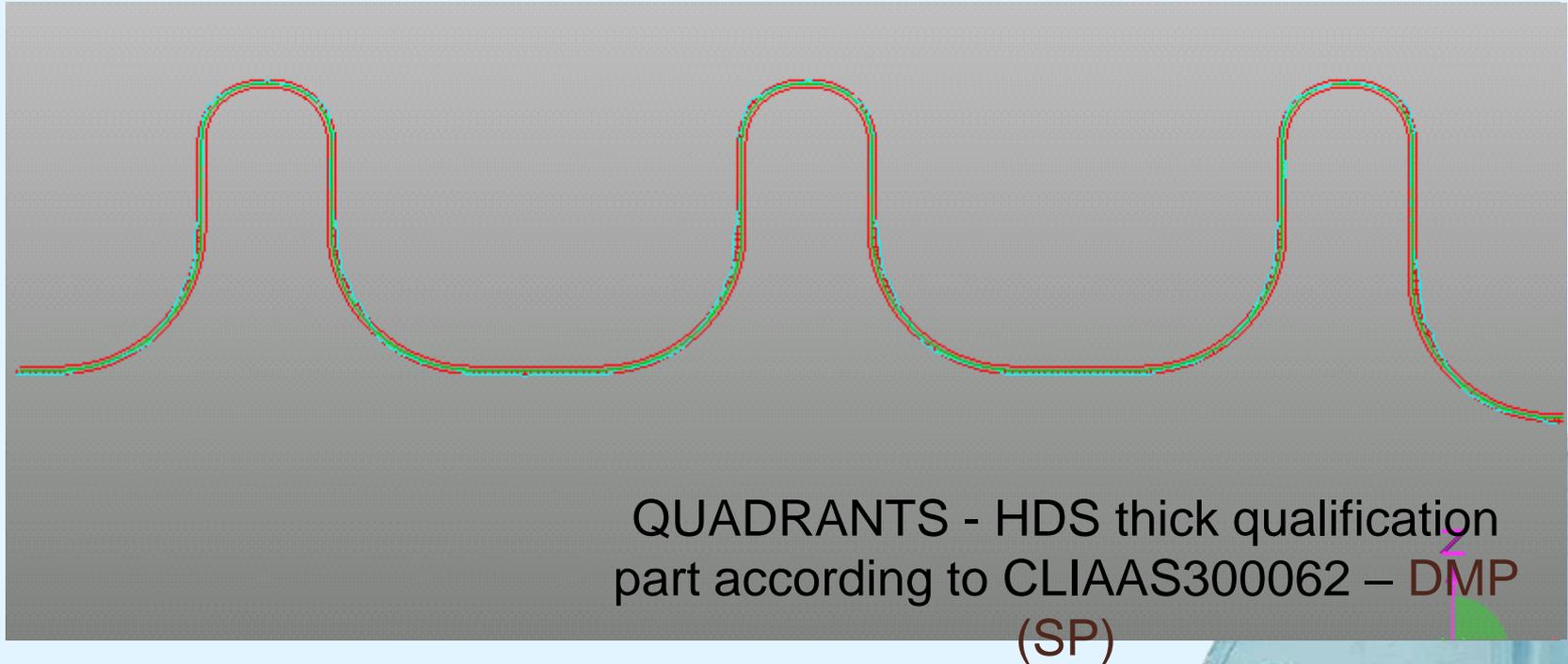
Einpassergebnis	X	Translation	Rotation	Überhöhung	550.0
	Y	0.0000	0.0000	Kommentar	
	Z	0.0005	0.0000		
		0.0000	0.0016		



Accelerating structures: alternative program

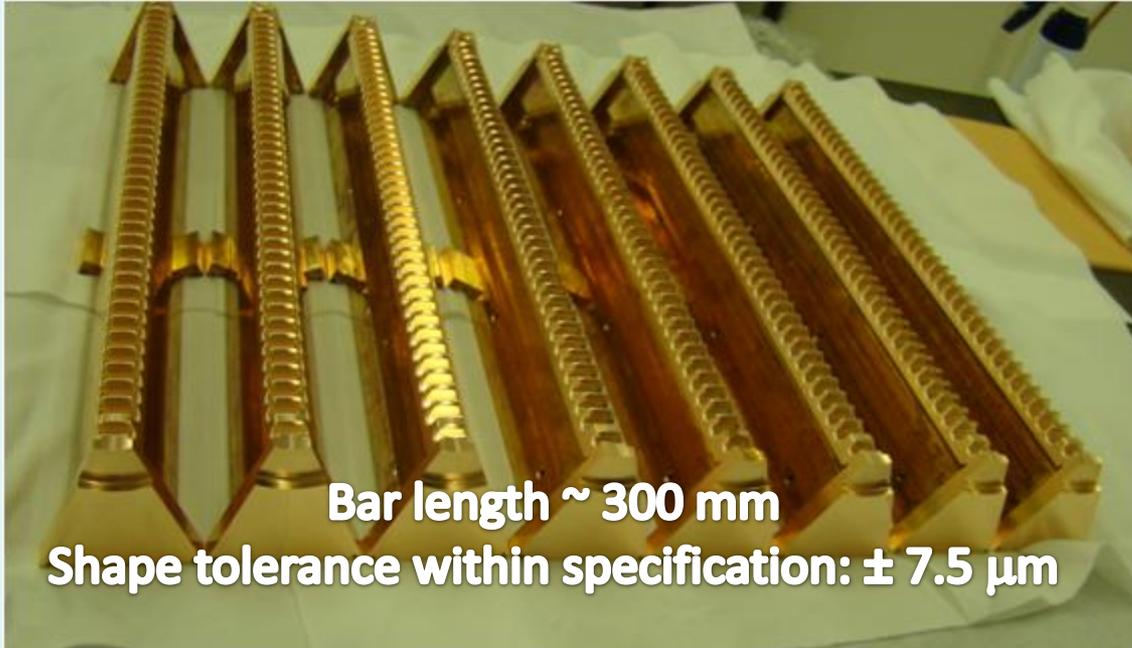
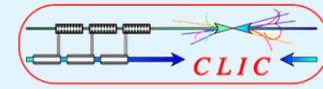


S. Atieh

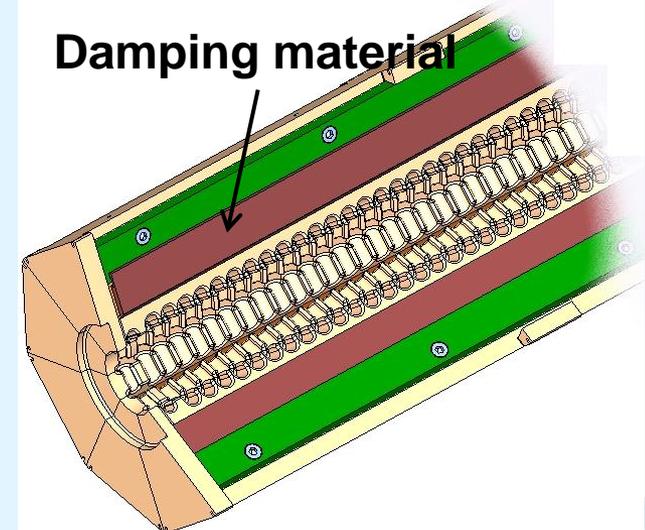


Origins translation: X 16 μm and Z -8 μm
Shape accuracy is respected $\pm 2.5 \mu\text{m}$

Fabrication of PETS at 11.4 GHz with damping material

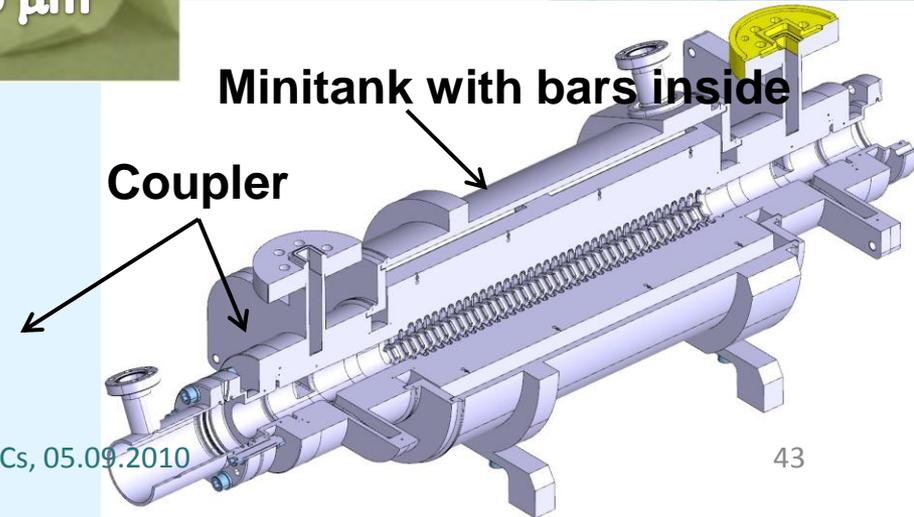


Bar length ~ 300 mm
Shape tolerance within specification: $\pm 7.5 \mu\text{m}$



Damping material

PETS for feasibility demonstration
- successfully tested at SLAC

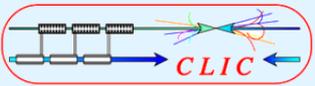


Minitank with bars inside

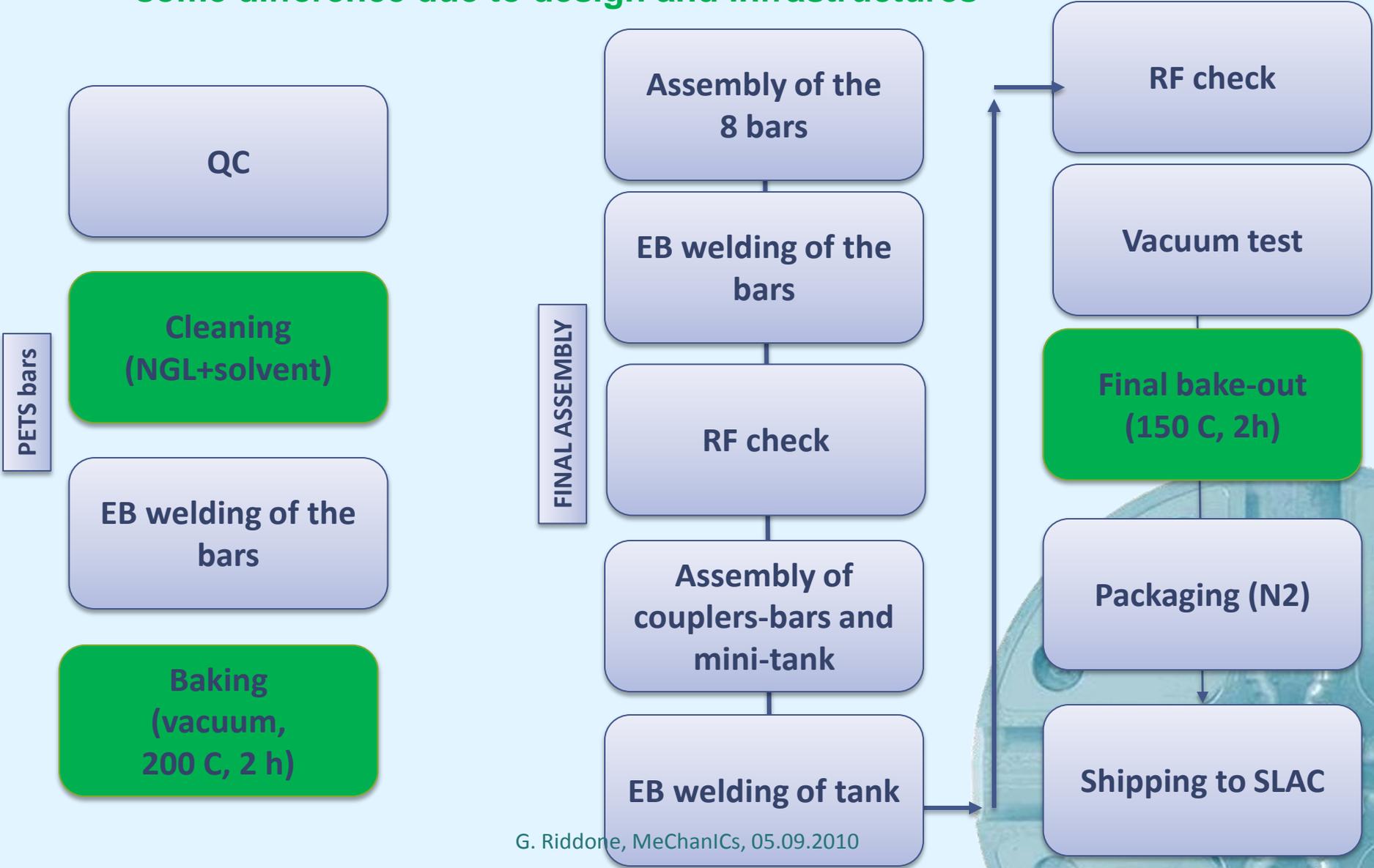
Coupler



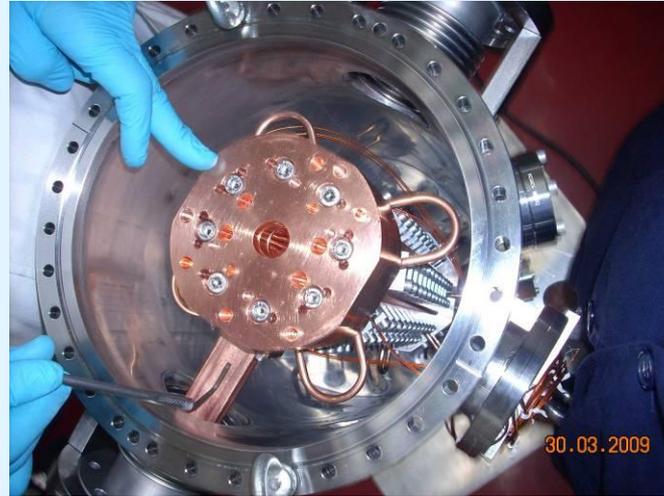
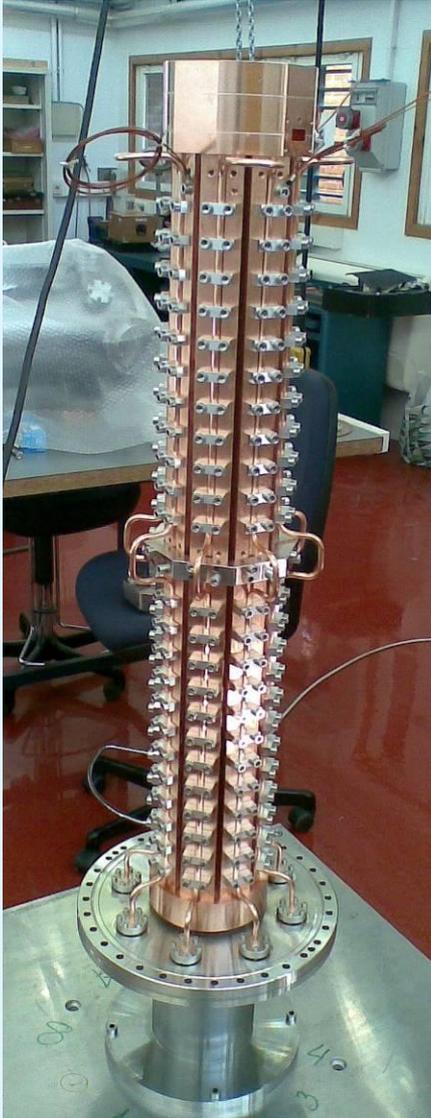
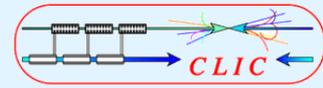
Fabrication flow for PETS (11,4 GHz)



Procedure as close as possible to the baseline, but some difference due to design and infrastructures



Fabrication of TBL PETS



Prototype made by CIEMAT using conventional UHV best practice for cleaning and handling
Coupler is brazed, no heat treatment for PETS itself

The **CERN production** will be assembled in a clean room,
The coupler will be vacuum brazed at CERN

Production capability

<i>PRODUCTION CYCLE (ac. structures)</i>				<i>PRODUCTION CYCLE (PETS @ 11.4 GHz)</i>			
Manufacturing	Assembly (bonding)	Tuning	Baking	Manufacturing	Assembly (EB welding)	RF meas.	Baking
10 wks	4 wks	2 wks	3 wks	10 wks	6 wks	1 wk	1 wk
Total: 19 wks (about 5 months)				Total: 18 wks (about 4.5 months)			

3 laboratories:

- ac. structures → SLAC/KEK and CERN
- PETS → CERN

6 qualified vendors for ac. structures: 3 (CERN), 2 (KEK), 1 (SLAC)

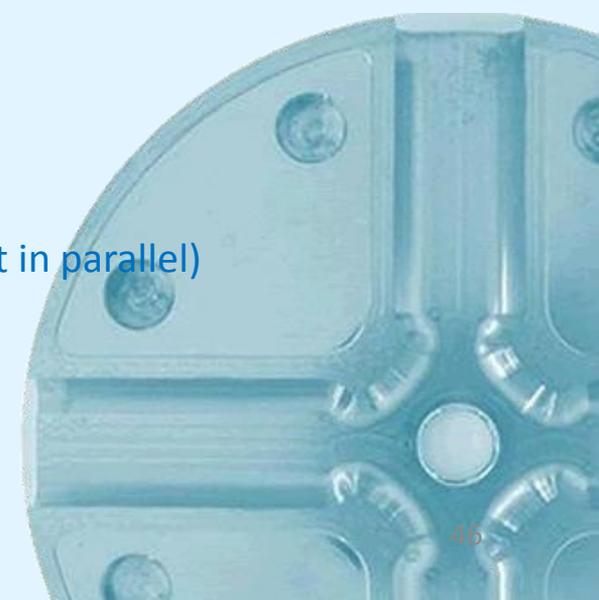
3 qualified vendors for PETS

For each structure, at least two units per lab. are manufactured (almost in parallel)

For KEK/SLAC made structure, the assembly/baking is made at SLAC

- e.g. baking of two structures in parallel

At present, potential capability up to 20. structures per year

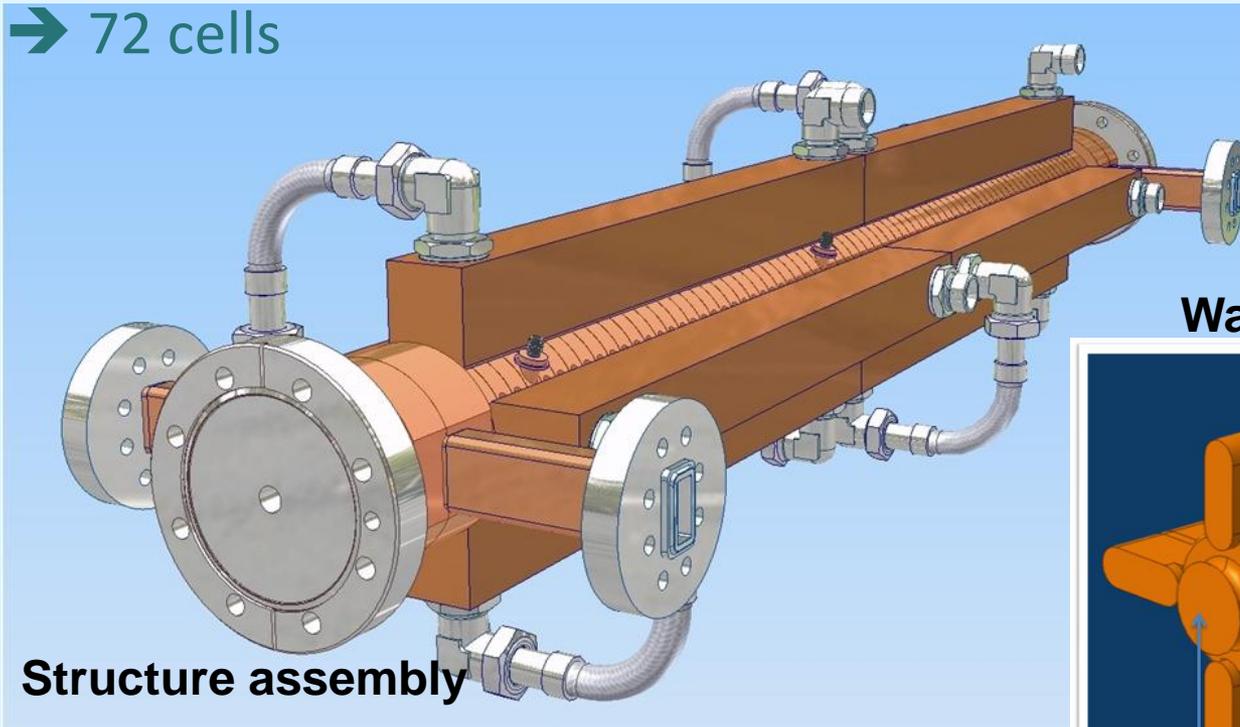


Other structures

Important involvement of other laboratories to exchange experience and to increase the market

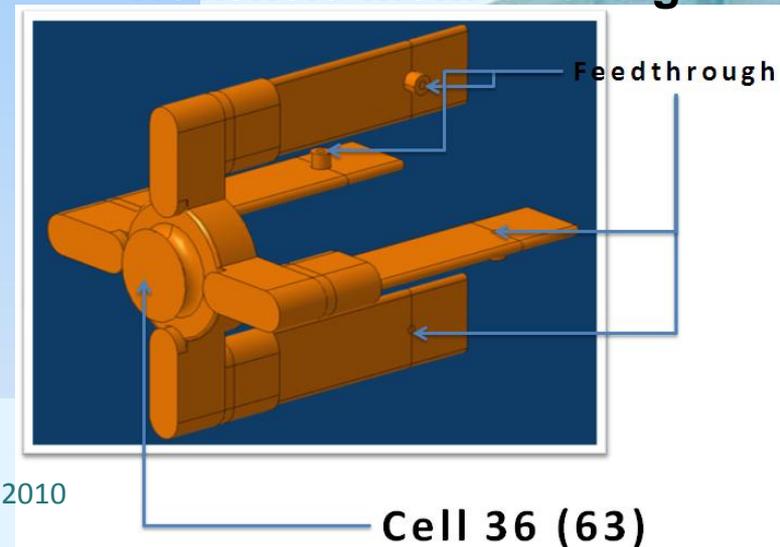
→ 900-mm long structures for PSI (X-FEL) and Elettra (Sincrotrone Trieste) with wakefield monitors

→ 72 cells



Structure assembly

Wakefield monitor design



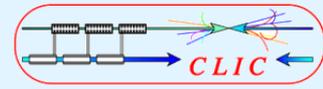
Assembly

To be studied/optimised

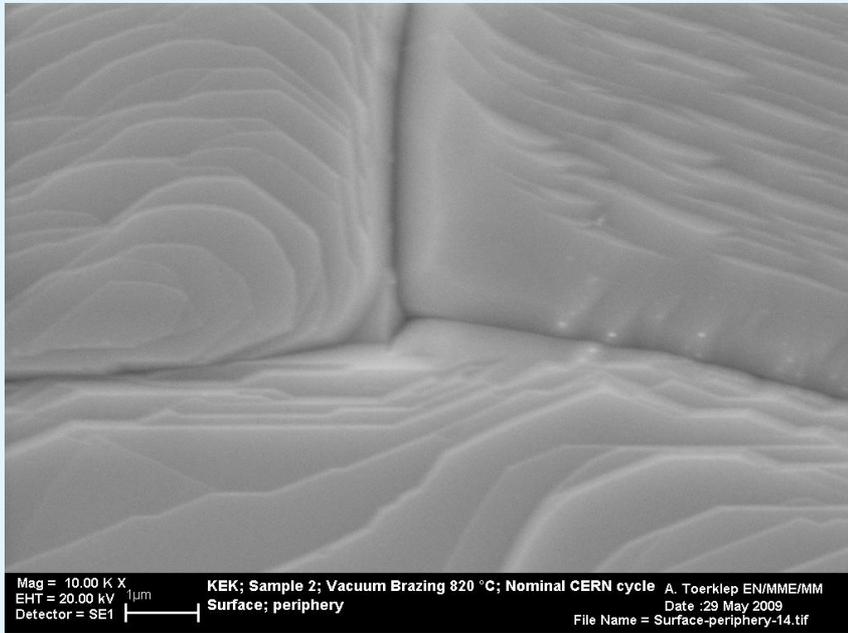
- **Baseline procedure:**
 - sequence of different steps to improve quality (e.g welding of flanges as one the last operations is dangerous)
 - Review of thermal cycles: T vs time
 - Minimization of thermal cycles
- Review of alignment procedure
- Cost effective assembly procedure



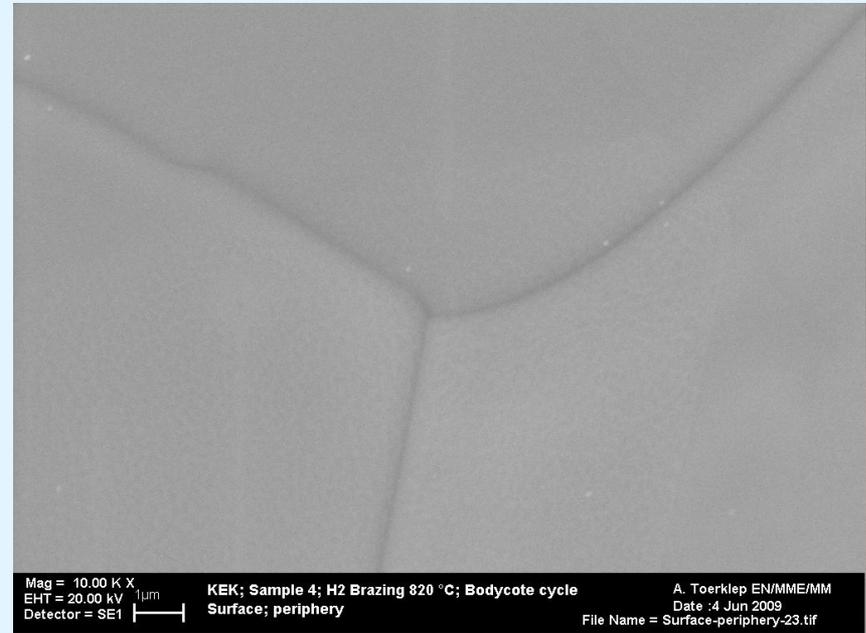
Vacuum brazing versus hydrogen brazing



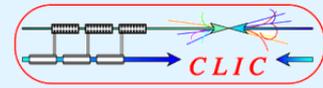
Vacuum brazing



Hydrogen brazing



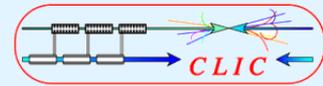
Extensive program launched to improve our understanding on the influence of different thermal cycles on the copper surface



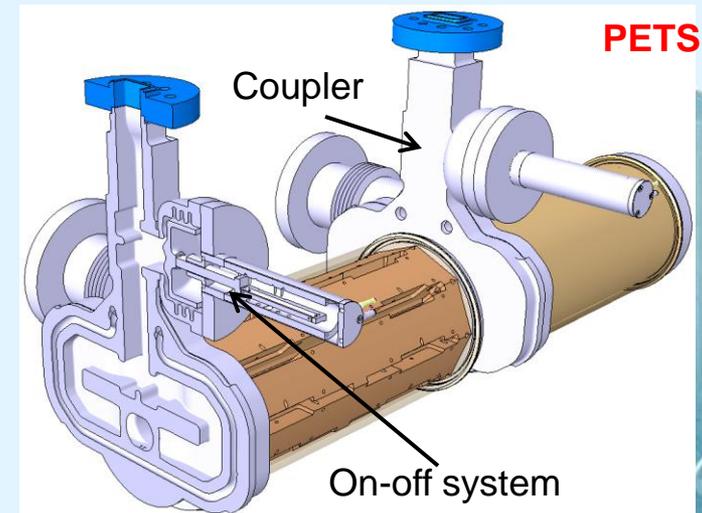
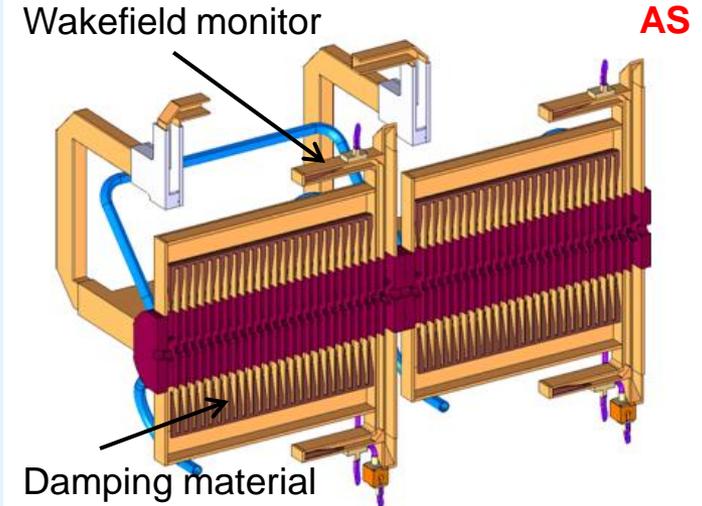
TOWARDS CLIC STRUCTURES



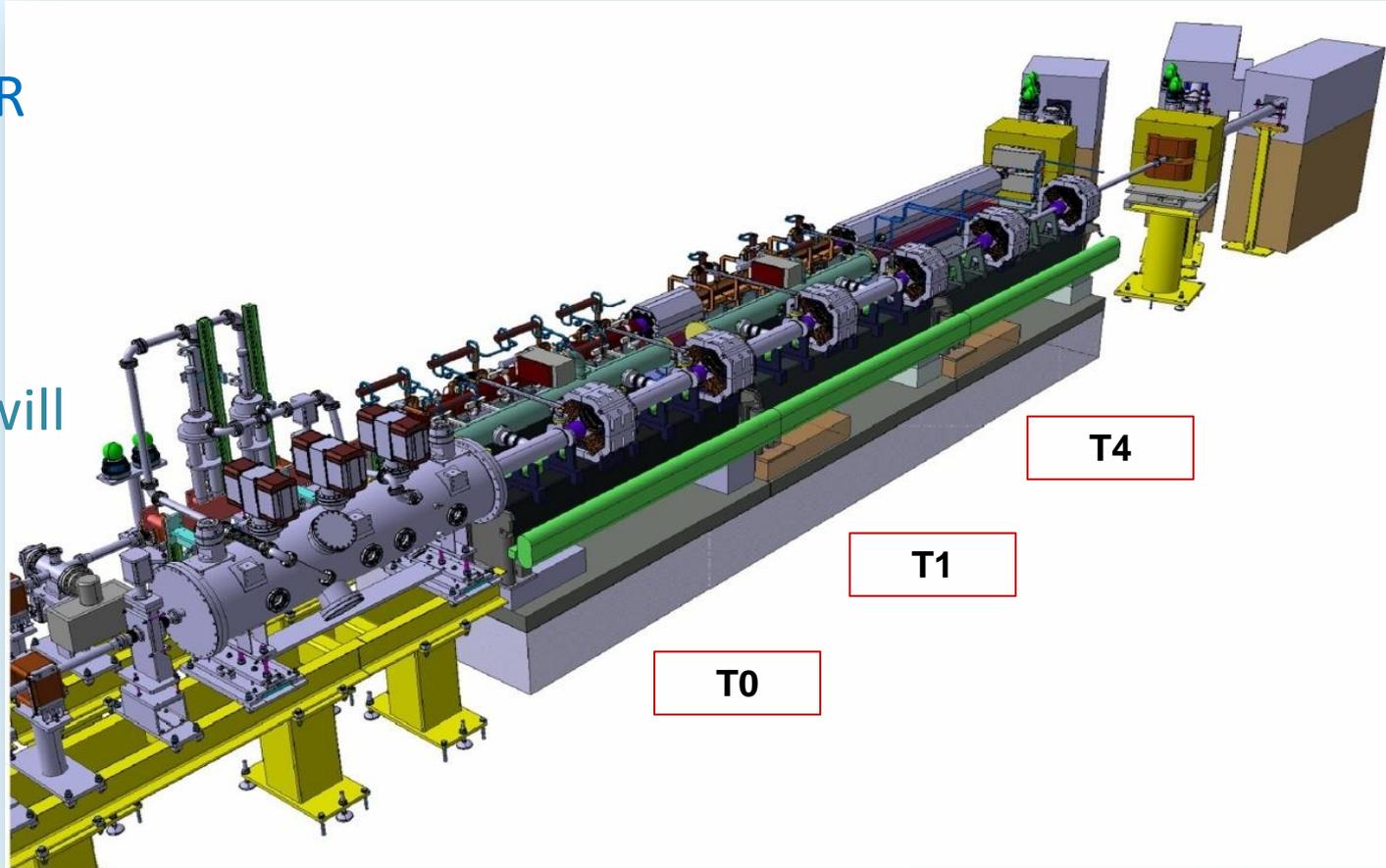
Towards CLIC structures



- CDR
 - Accelerating structure with all features: damping material, wakefield monitor and technical systems; under eng. design (**first structure at the end of 2010**). Assembly test with a prototype structure are scheduled in the coming weeks.
 - PETS with on-off system: under design. **On-off system to be tested in Q1, 2011**
 - **Cost estimate** is needed for CDR: dedicated studies with three companies/institutes



- From CDR to TDR
 - Main linac prototype modules (3 by end of 2012) will be built to validate the technical systems in an integrated approach.



- These modules will contain accelerating structures and PETS with all required features
- Industrialization and mass production development in collaboration with companies

Conclusions

- Fabrication of X-band micro-precision RF structure is very challenging and it involves several steps, technologies and quality controls
- NLC/JLC fabrication technology validated for CLIC accelerating structures to 100 MV/m
 - ➔ CERN implementing NLC/JLC procedures, but optimization is needed
- Production capability in Europe has to increase: at present only few firms qualified and the final product is not always within tolerances ➔ involvement of other laboratories to exchange experience and expertise is mandatory
- Fabrication procedures are to be developed and cost-performance ratio improved
- CLIC structures with all features under design: first unit ready by end of this year
- Main linac prototype modules for CLEX will include CLIC several structures: 2011-2013
- Industrialization, mass production and cost study under way